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http://www.cas.org/infopolicy.html

=> s oxetane

L1 4682 OXETANE

=> s acryloyl

L2 11113 ACRYLOYL

=> s 11 and 12

L3 28 L1 AND L2

=> d 1-28 bib abs

L3 ANSWER 1 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN

AN 2007:116310 CAPLUS

DN 146:172007

TI Fabrication of optical members including index-different sections with variety of shape

N Koho, Satoshi; Eriyama, Yuichi

PA Jsr Ltd., Japan

SO Jpn. Kokai Tokkyo Koho, 17pp.

CODEN: JKXXAF

DT Patent

LA Japanese FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PΙ	JP 2007025091	A	20070201	JP 2005-205132	20050714

PRAI JP 2005-205132 20050714

B The process involves these steps; applying compns. of (A) radical monomers, (B) radical initiators, (C) cationic polymerization monomers, and optionally (D) cationic photopolymm. initiators on supports, exposing the same to light in atmospheric containing ≥1 volume% 0, and heating or exposing the same to light with different wavelength from that of the former, to form polymers of C around and/or upon the preformed polymers of A. The C polymers have smaller n than that of A polymers. Waveguides or microlens arrays can be nanufactured as above without development stage.

- L3 ANSWER 2 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 2006:1031534 CAPLUS
- DN 145:357658
  - Thermally radical- and thermally cationic-curable vinyl polymer compositions with low viscosity and high mechanical strength
- IN Tamai, Hitoshi; Nakagawa, Yoshiki
- PA Kaneka Corp., Japan
- SO Jpn. Kokai Tokkyo Koho, 44pp.
- CODEN: JKXXAF
- DT Patent
- LA Japanese
- FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI	JP 2006265483	A	20061005	JP 2005-89220	20050325
PRAI	JP 2005-89220		20050325		
7.70	mb = 61	£	-1		. 1

AB The compnis, useful for seals and gaskets, comprise vinyl polymers having ≥2 O2CCRatCH2 (I. Ra = H, C1-20 organic group) in a mol. containing ≥1 I at end groups and epoxides and/or oxetane compds.
Thus, a composition comprising acryloyl-terminated Bu acrylate—Et acrylate—2-methoxyethyl acrylate copolymer manufactured by living atom transfer radical polymerization (ATRP) in the presence of CUBr 70, benzoperoxide (Nyper BW) 0.7, 3,4-epoxycylohexylmethyl 3,4-epoxycylohexyanecarboxylate (Celloxide 2021P) 30, thermally cationic polymerization catalyst of (2-butenyl)tetramethylenesulfonium hexafluoroantimonate (Adeka Opton CP 77) 0.45 part was hot-pressed into a sheet showing 30% modulus (IIS K

6301) 0.22 MPa, strength at break 1.42 MPa, and elongation at break 115%.

- L3 ANSWER 3 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 2006:489898 CAPLUS
- DN 145:9782
- TI Coating compositions with good scratch, acid, and solvent resistance for automobile bodies
- IN Maeda, Shinichi; Saito, Yoshikazu; Toyama, Masayuki; Hayama, Yasushi
- PA Mitsubishi Rayon Co., Ltd., Japan SO Jpn. Kokai Tokkyo Koho, 28 pp.
- CODEN: JKXXAF
- DT Patent
- LA Japanese
- FAN.CNT 1

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE

PI JP 2006131670 A 20060525 JP 2004-319366 20041102 PRAI JP 2004-319366 20041102

AB Title coating compns. comprise (A) a compound having a (meth) acryloyl group and an anhydride group formed by at least two carboxylic acid groups or one ester group and a carboxylic acid group, an acrylic copolymer having at least an epoxy group or an oxetane group, and a radical polymerization initiator. Thus, styrene 20, tridecyl methacrylate 15, glycidyl methacrylate 45, and 4-hydroxybutyl acrylate were polymerized to give a copolymer with epoxy equivalent 315 q/equiv and

weight average
mol. weight 5000, 315 parts of which was mixed with 2-acryloyloxy trimellitic
anhydride obtained from 2-hydroxyethyl acrylate and trimellitic anhydride

283, 1-hydroxycyclohexylphenylketone 18, Sanol LS 765 12, tetraethylphosphonium bromide 6, and Modaflow 1.2 parts, applied on a coated steel plate, dried at 160° for 30 min, and irradiated with a UV ray to give a test piece, showing good acid, solvent, and scratch resistance, and gloss retention, and pencil hardness F.

- L3 ANSWER 4 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 2006:199643 CAPLUS
- DN 145:505777
- TI Development of high performance photo-curable polymers and oligomers using novel reactions of oxetane compounds
- AU Nishikubo, Tadatomi; Kameyama, Atsushi
- CS Department of Applied Chemistry, Faculty of Engineering, Japan
- SO RadTech Europe Ö5: UV/EB--Join the Winning Technology, [Conference Proceedings], Barcelona, Spain, Oct. 18-20, 2005 (2005), Volume 2, 43-47 Publisher: RadTech Europe Association, The Hague, Neth. CODEN: 69HVYN
- DT Conference; General Review
- LA English
- AB A review. The authors recently found many new addition reactions of oxetanes with certain reagents such as phenols and carboxylic acids using certain quaternary onium salts or crown ether complexes as catalysts. More recently, we also found new anionic ring-opening polymerization of oxetanes containing pendant hydroxyl groups and alternating anionic ring-opening copolymn. of oxetanes with cyclic carboxylic anhydrides using appropriate catalyst system. These reactions have been widely applied to the synthesis of polymers and thermo-setting reactions of oxetane resins. In this paper, we would like to introduce the application of these new reactions for the synthesis of high performance photo-curable polymers and oligomers containing pendant or terminal (meth)acryloyl groups. The authors also report the photochem, property of the resulting polymers and oligomers. Furthermore, the authors would like to talk about the synthesis of certain calixarenes and poly(imide)s containing oxetane groups as high performance materials and their photochem. reaction.

RE.CNT 15 THERE ARE 15 CITED REFERENCES AVAILABLE FOR THIS RECORD ALL CITATIONS AVAILABLE IN THE RE FORMAT

- L3 ANSWER 5 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 2005:1075860 CAPLUS
- DN 143:368070
- TI Photoradically/photocationically curable compositions with low viscosity
- IN Okada, Kenji; Nakagawa, Yoshiki
- PA Kaneka Corporation, Japan
- SO PCT Int. Appl., 65 pp.

```
CODEN: PIXXD2
DΤ
     Patent
LA
    Japanese
FAN.CNT 1
                       KIND DATE APPLICATION NO.
                       ----
                        A1 20051006 WO 2005-JP5510 20050325
    WO 2005092981
        W: AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH,
             CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD,
             GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC,
             LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NA, NI,
             NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SM,
             SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW
         RW: BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW, AM,
             AZ, BY, KG, KZ, MD, RU, TJ, TM, AT, BE, BG, CH, CY, CZ, DE, DK,
             EE, ES, FI, FR, GB, GR, HU, IE, IS, IT, LT, LU, MC, NL, PL, PT,
            RO, SE, SI, SK, TR, BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG
                               20051006
                                         CA 2005-2561169
     CA 2561169
                         A1
                                         EP 2005-727009
     EP 1728826
                         A1
                               20061206
        R: AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IS, IT, LI, LT, LU, MC, NL, PL, PT, RO, SE, SI, SK, TR
                    A
                             20070328
                                           CN 2005-80009881
                             20040326
PRAI JP 2004-92556
                        A
    UP 2004-92556 A
WO 2005-JP5510 W
                               20050325
    Title compns. comprise (A)≥2 acryloyl group-containing vinyl
AB
     polymers (≥1 acryloyl group is a terminal group), (B)
     epoxy compds. and.or oxetane compds., (C) photoradical
     initiators, and (D) photocationic initiators. Thus, Bu acrylate, Et
     acrylate, and 2-methoxyethyl acrylate were polymerized in the presence of
     copper (I) bromide, pentamethyldiethylenetriamine, and di-Et
     2,5-dibromoadipate, potassium acrylate was added therein and reacted to
     give acryloyl-terminated copolymer with number average mol. weight 16,900
     and polydispersity 1.14, 100 parts of which was mixed with
     2,2-diethoxyacetophenone 0.2, Epolite 4000 30, Adeka Optomer SP 172 1.5,
     and Irganox 1010 1 parts to give a composition with viscosity 150 Pa-s at
     23°, which was cured by irradiation to give a cured product, showing
     30% modulus 0.52 MPa, tensile strength at break 0.94 MPa, and elongation
     at break 52%.
RE.CNT 9
             THERE ARE 9 CITED REFERENCES AVAILABLE FOR THIS RECORD
             ALL CITATIONS AVAILABLE IN THE RE FORMAT
     ANSWER 6 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
AN
     2005:823679 CAPLUS
DN
     143:212295
ΤI
     Preparation of polymerizable (meth)acryloyl group-containing
    oxetane monomers
IN
    Kamata, Hirotoshi; Morinaka, Katsutoshi; Uchida, Hiroshi
     Showa Denko K.K., Japan
     PCT Int. Appl., 21 pp.
     CODEN: PIXXD2
DΤ
     Patent
LA
    English
FAN.CNT 1
     PATENT NO.
                       KIND
                               DATE APPLICATION NO.
    WO 2005075445 A2
                               20050818 WO 2005-JP2381 20050209
```

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W: AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH,
             CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD,
             GE, GH, GM, HR, HU, ID, IL, IN, IS, KE, KG, KP, KR, KZ, LC, LK,
             LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NA, NI, NO,
             NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SY, TJ,
             TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW
         RW: BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW, AM,
             AZ, BY, KG, KZ, MD, RU, TJ, TM, AT, BE, BG, CH, CY, CZ, DE, DK,
             EE, ES, FI, FR, GB, GR, HU, IE, IS, IT, LT, LU, MC, NL, PL, PT,
             RO, SE, SI, SK, TR, BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML,
             MR, NE, SN, TD, TG
     JP 2005255671
                                20050922
                                            JP 2005-24723
                                                                    20050201
                          Α
     EP 1713787
                          A2
                                20061025
                                            EP 2005-710281
                                                                    20050209
         R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT,
             IE, SI, LT, LV, FI, RO, MK, CY, AL, TR, BG, CZ, EE, HU, PL, SK,
             BA, HR, IS, YU
     US 2007060760
                          A1
                                20070315
                                            US 2006-588072
                                                                    20060731
PRAI JP 2004-32867
                          Α
                                20040210
     US 2004-545488P
                                20040219
                          Ρ
     WO 2005-JP2381
                          147
     MARPAT 143:212295
OS
GΙ
```





AB Polymerizable (meth)acryloyl group-containing oxetane [I; A = OR2, direct bond; R2 = divalent hydrocarbyl (which may contain an oxygen atom in the main chain); R1 = H, CH3; R3 = Cl-6 (un)branched alkylene; R4 = Cl-6 (un)branched alkyl) monomers are prepared in high yield and selectivity by the addition reaction of (meth)acrylate isocyanates H2C:C(R1)CO(A)NCO with 3-(hydroxyalkyl)-substituted oxetanes (II) in the presence of a tertiary amine or tin-compound catalyst. Thus, 2-acryloyloxyethyl isocyanate was mixed in Et acetate containing dibutyltin dilaurate and reacted with 3-ethyl-3-(hydroxymethyl)oxetane, producing an oxetanyl group-containing methacrylate ester monomer (III).

DN 142:482780

L3 ANSWER 7 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN

AN 2005:428262 CAPLUS

Electrically conductive polymers containing condensed indoline rings and their manufacture

IN Kodera, Tatsuya

Mitsubishi Paper Mills, Ltd., Japan PA

Jpn. Kokai Tokkyo Koho, 28 pp. CODEN: JKXXAF

Patent

T.A Japanese

FAN.CNT 1

PI JP 2005126493 A 20050519 JP 2003-36109 PRAI JP 2003-361092 20031021	92 20031021	

- AR The manufacturing method of polymers, useful for electrophotog. photoreceptors, electroluminescent devices, etc., includes polymerizing I (R10 = alkyl, aryl, heterocyclic; R11 = H, amino, alkyl, alkoxy; R12 = H, alkyl; Ar2 = divalent group; Z3 = group forming saturated C5-8 ring). Manufacturing method including polymerizing mixts. of I and XCH2(OCH2CH2)mO2CC:CH2R2 (II; X= 3-R1-3-oxetanyl; R1,2 = H, alkyl; m = 0-2) are also claimed. Thus, I (R10 = Ph, R11 = H, R12 = Me, Ar2 = phenylene, Z3 = cyclopentane) and II (X= 3-R1-3-oxetanyl; R1 = Et, R2 = Me, m = 0) were polymerized in the presence of AIBN to give a copolymer with Mn 63,000 and Mw 92,000. A multilayer photoreceptor containing charge-transporting layer comprising the copolymer showed electrostatic potential -600 V at applied voltage -6 kV and light exposure for decreasing the potential in half (E1/2) 1.0 lx-s.
- ANSWER 8 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN L3
- AN 2005:155387 CAPLUS
- DN 142:246263
- Dental adhesive composition
- ΙN Anzai, Misaki; Kawaguchi, Motoki
- PA
- Dentsply-Sankin K. K., Japan Eur. Pat. Appl., 13 pp. CODEN: EPXXDW
- Patent.
- LA English

FAN.CNT 1

DATE

							-									-			
PI	EP	1508	321			A1		2005	0223		EP 2	004-	1951	8		2	0040	817	
		R:	AT,	BE,	CH,	DE,	DK,	ES,	FR,	GB,	GR,	IT.	LI,	LU,	NL,	SE,	MC,	PT,	
			ΙE,	SI,	LT,	LV,	FI,	RO,	MK,	CY,	AL,	TR,	BG,	CZ,	EE,	HU,	PL,	SK,	HR
	JΡ	2005	0659	02		A		2005	0317		JP 2	003-	2983	63		2	0030	822	
	US	2005	0547	49		A1		2005	0310		US 2	004-	9203	58		2	0040	818	
PRAI	JP	2003	-298	363		A		2003	0822										
AB	A	denta	l ad	nesi	те с	ompos	siti	on w	hich	can	qui	ckly	be 1	hard	ened	eve:	n in	the	
	pre	esenc	e of	oxy	gen '	with	out	usin	ga:	radi	cal	gene	rati	ng a	gent	suc	h as	a	
	pe:	roxid	e or	a pl	noto	poly	nn.	init	iato:	r, t	o gi	ve h	igh l	bond	str	engtl	h,		
	COL	mpris	es a	carl	ooxy.	lic a	acid	hav	ing a	a (m	eth)	acry	loyl	gro	up a:	nd a			
	ca:	rboxy	l gr	oup,	bot	n of	whi	ch a	re a	ttac	hed	to a	n ar	omat.	ic r	ing;	a b	isph	enol A

APPLICATION NO.

derivative having 2 (meth)acryloyl groups; a hydroxylalkyl (meth) acrylate; a (meth) acrylate derivative having an acid group; and at least one polymerization initiator selected from the group consisting of aromatic

amines, aliphatic amines, and aromatic sulfinic acids, the composition being

substantially free from any radical polymerization initiator. Thus, a composition was obtained from

different methacryloyl monomers.

THERE ARE 10 CITED REFERENCES AVAILABLE FOR THIS RECORD RE.CNT 10 ALL CITATIONS AVAILABLE IN THE RE FORMAT

ANSWER 9 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN L3

KIND DATE

AN 2005:13763 CAPLUS

PATENT NO.

- DN 142:103247
- TI High-sensitivity shrink-proof holographic recording materials containing epoxides, their manufacture, and their recording
- TN Sasa, Nobumasa
- PA Konica Minolta Medical & Graphic, Inc., Japan
- Jpn. Kokai Tokkvo Koho, 20 pp. SO
- CODEN: JKXXAF
- DΨ Patent
- LA Japanese
- FAN.CNT 1

AB

	PA:	PENT NO.	KIND	DATE	P	APPLICATION NO. DATE	DATE		
					-				
PI		2005003958	A	20050106	ċ	JP 2003-167597 2003	0612		
PRAI	JP	2003-167597		20030612					

OS MARPAT 142:103247

The holog, recording materials contain (A) epoxides containing ≥1 substituted oxirane rings on  $\alpha$  and/or  $\beta$  sites of oxirane rings, epoxidized fatty acid esters, epoxidized fatty acid glycerides, (B) photopolymn. initiators, and optionally, (C) oxetane ring-containing compds. and/or vinyl ethers, (D) (meth)acryloyl group-containing compds. and photoradical polymerization initiators. The holog, recording materials form matrixes by ≥1 polymerization reaction selected from cationic epoxy polymerization, cationic vinyl ether polymerization, cationic

alkenvl ether polymerization, cationic arene ether polymerization, cationic ketene

polymerization, epoxy-amine step polymerization, epoxy-mercaptan step polymerization, unsatd.

ester-amine step polymerization, unsatd. ester-mercaptan step polymerization, vinyl-silicone hydride step polymerization, isocyanate-hydroxyl step polymerization, and

isocyanate-amine step polymerization In another alternative, the holog-recording materials form matrixes by curing of inorg, or organic matrix precursors which may comprise RnM(OR')4-n (M = 23-valent metal element, preferably, Si, Ti, Ge, Zr, V, Al; R = alkyl, allyl; R' = CS4 lower alkyl; n = 1, 2). The holog, recording materials are are manufactured by mixing matrix-forming substances, their curing to give matrixes, and irradiation with actinic light for holog, recording.

```
ANSWER 10 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
AN
    2004:1014409 CAPLUS
DN
    142:7357
ΤI
    Active energy curable resin compositions with good curability and low
    reflectance angle for optical disks
    Makino, Shinji
IN
    Mitsubishi Rayon Co., Ltd., Japan
PA
SO
    Jpn. Kokai Tokkyo Koho, 17 pp.
    CODEN: JKXXAF
DT
    Patent
LA
    Japanese
FAN.CNT 1
    PATENT NO.
                       KIND DATE
                                         APPLICATION NO.
                       ----
                              -----
                                          -----
                              20041125
    JP 2004331872
                                         JP 2003-131585
                                                                20030509
PRAI JP 2003-131585
                              20030509
    Title compns. comprise (A) compds. having ≥2 oxetane
    rings, (B) compds. having ≥2 oxirane rings, (C) cationic
    photoinitiators, (D) compds. having ≥1 (meth) acryloyl
    group, and (E) radical photoinitiators. Thus, a composition comprising OXT 121
    25, YD 8125 bisphenol A diglycidyl ether 25, UVI 6990 photoinitiator 3.0,
    U 2PHA diacrylate 5.0, and Irgacure 184 1.0 parts was applied on a
    silver-coated Panlite AD 9000TG optical disk and irradiated with a high
    pressure mercury lamp to give a test piece with reflectance angle
    0.16° initially and 0.06° after durability test,
    transmittance 91% at 400 nm, 93% at 500 nm, and 93% at 700 nm, good
    surface hardness and reliability.
    ANSWER 11 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
AN
    2004:996235 CAPLUS
    141:429659
    Photocuring/thermosetting ink-jet composition and printed wiring board
    using same
IN
    Kakinuma, Masahisa; Kusama, Masatoshi; Ushiki, Shigeru
PA
    Taiyo Ink Manufacturing Co., Ltd., Japan
SO
    PCT Int. Appl., 21 pp.
    CODEN: PIXXD2
DТ
    Patent
LA
    Japanese
FAN.CNT 1
    PATENT NO.
                       KIND
                              DATE APPLICATION NO. DATE
                              20041118 WO 2004-JP6029
PΙ
    WO 2004099272
                       A1
```

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RW: BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW, AM,
            AZ, BY, KG, KZ, MD, RU, TJ, TM, AT, BE, BG, CH, CY, CZ, DE, DK,
            EE, ES, FI, FR, GB, GR, HU, IE, IT, LU, MC, NL, PL, PT, RO, SE,
            SI, SK, TR, BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE,
            SN, TD, TG
    EP 1624001
                              20060208
                                          EP 2004-731714
        R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT,
            IE, SI, FI, RO, CY, TR, BG, CZ, EE, HU, PL, SK
                        A
                             20060607
                                         CN 2004-80012609
                                                                 20040507
                        A1
    US 2006058412
                              20060316
                                         US 2005-269836
                                                                 20051109
PRAI JP 2003-131742
                        A
                              20030509
    WO 2004-JP6029
                        W
                              20040507
AB
   A photocuring/thermosetting ink-jet composition contains (A) a monomer having a
     (meth)acryloyl group and a thermosetting functional group in the
    mol., (B) a photoreactive diluent other than the component (A) having a
    weight-average mol. weight of not more than 700, and (C) a photopolymn.
initiator,
    and has a viscosity of not more than 150 mPa·s at 25°. A
    solder resist pattern is directly drawn on a printed wiring board by an
    ink-jet printer using the above-mentioned composition, and the pattern is
    primarily cured by irradiation with an active energy beam and then further
    cured by heat.
RE.CNT 15
             THERE ARE 15 CITED REFERENCES AVAILABLE FOR THIS RECORD
             ALL CITATIONS AVAILABLE IN THE RE FORMAT
    ANSWER 12 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
L3
AN
    2003:1000504 CAPLUS
DN
    141:242819
    Product class 4: organometallic complexes of copper
AU
    Heaney, H.; Christie, S.
CS
    Dept. of Chemistry, University of Loughborough, Loughborough, LE11 3TU, UK
SO
    Science of Synthesis (2004), 3, 305-662
    CODEN: SSCYJ9
PB
    Georg Thieme Verlag
    Journal; General Review
LA
   English
   A review. The use of copper and related complexes in applications to organic
    synthesis is reviewed.
RE.CNT 1706 THERE ARE 1706 CITED REFERENCES AVAILABLE FOR THIS RECORD
             ALL CITATIONS AVAILABLE IN THE RE FORMAT
L3
   ANSWER 13 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
AN
    2003:929612 CAPLUS
DN
    139:397036
    Oxetane-base polyol (meth) acrylates, their curable compositions,
    and hard coatings containing them with good heat and water resistance
    Sauchi, Yasuvuki; Sasaki, Hiroshi
PA
    Toa Gosei Chemical Industry Co., Ltd., Japan
    Jpn. Kokai Tokkyo Koho, 13 pp.
    CODEN: JKXXAF
    Patent
LA
    Japanese
FAN.CNT 1
    PATENT NO.
                       KIND
                              DATE
                                         APPLICATION NO. DATE
PI JP 2003335854
                       A
                               20031128
                                          JP 2002-143719
```

TI

DT

TN

DΤ

PRAI JP 2002-143719

20020517

AB The invention relates to the (meth)acrylates having ≥2 (meth) acryloyl groups manufactured by heat-cationic-polymerizing I (Rl = H, alkyl, aryl, arylalkyl) to obtain polyols and esterifying them with (meth)acrylic acid. Thus, a composition comprising 3-ethyl-3-(hydroxymethyl)oxetane homopolymer acrylate was applied on a substrate and UV-cured to give a coating showing pencil hardness 4H, storage modulus 1.08 + 109 at 210°, and water absorption 1.32%.

- L3 ANSWER 14 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 2003:368907 CAPLUS
- DN 138:369365
- TI Oxetane-containing (meth)acrylate esters, their manufacture, and their use as dental monomers and monomers for grafting polyolefins
- N Miyazaki, Kazuhisa; Ota, Seiji; Akie, Hideyuki
- PA Mitsui Chemicals Inc., Japan
- SO Jpn. Kokai Tokkyo Koho, 6 pp.
- CODEN: JKXXAF
- DT Patent
- LA Japanese
- FAN.CNT 1

PATENT	NO.	KIND DATE APPLICATION NO.					DATE		
PRAI JP 200	3137878 1-332394 138:369365	A	20030514 20011030	JP	2001-3323	394	20011030		

$$\begin{array}{c} \text{CH}_2 \\ \text{R}^1 \\ \text{O} - (\text{R}^2 - \text{O} - \text{CH}_2 - \text{CO})_{\text{II}} - \text{O} \end{array}$$

AB Title esters I [Rl = H, Me; R2 = (ether bond-containing) linear or branched alkylene; R3 = linear alkyl; n = 1-4], useful for coatings and adhesives as well, are manufactured by ring-cleavage esterification of lactones II [R2 = same as above) with 3-alkyl-3-hydroxymethyloxetane in the presence of base catalysts, followed by esterification of the resulting products with (meth)acryloyl halide. Thus, 1,4-dioxan-2-one was reacted with 3-ethyl-3-hydroxymethyloxetane in the presence of K2CO3 to give 28% 3-ethyl-3-oxetanylmethyl 2-hydroxyethoxyacetate, which was esterified with

acryloyl chloride to give 40% 3-ethyl-3-oxetanylmethyl 2-acryloxyethoxyacetate.

- ANSWER 15 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- 2003:366797 CAPLUS AN
- DN 138:369360
- Oxetane-containing (meth) acrylate esters, their manufacture, and their use as dental monomers and monomers for grafting polyolefins
- Mivazaki, Kazuhisa; Ota, Seiji IN
- PA Mitsui Chemicals Inc., Japan
- SO Jpn. Kokai Tokkyo Koho, 6 pp. CODEN: JKXXAF
- DТ Patent
- T.A Japanese
- FAN CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE		
PI	JP 2003137877	A	20030514	JP 2001-330883	20011029		
PRAI	JP 2001-330883		20011029				
OS	MARPAT 138:369360						

- GI
- $\begin{array}{c} R^{1} \\ H_{2}C = C Co \Big[ O R^{2} CO \Big] O CH_{2} R^{3} \\ n \end{array}$
- Title esters I [R1 = H, Me; R2 = (ether bond-containing) linear or branched AB alkylene; R3 = linear alkyl; n = 1-4], useful for coatings and adhesives as well, are manufactured by transesterification between HO(R2CO2)nR4 (R2, R4, n = same as above) and 3-alkyl-3-hydroxymethyloxetane in the presence of catalysts, followed by esterification of the resulting products with (meth)acryloyl halide. Thus, Et lactate was reacted with 3-ethyl-3-hydroxymethyloxetane in the presence of Ti(OCHMe2)4 to give 80% 3-ethyl-3-oxetanylmethyl lactate, which was esterified with acryloyl chloride to give 89% 3-ethyl-3-oxetanylmethyl 2-acryloxypropanoate.
- L3 ANSWER 16 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 2003:352823 CAPLUS
- DN 139:85711
- Combining Covalent and Noncovalent Cross-Linking: A Novel Terpolymer for Two-Step Curing Applications
- El-Ghayoury, Abdelkrim; Hofmeier, Harald; de Ruiter, Barteld; Schubert, ΑU Ulrich S.
- Laboratory of Macromolecular Chemistry and Nanoscience, Eindhoven University of Technology and Dutch Polymer Institute, Eindhoven, 5600, Neth.
- Macromolecules (2003), 36(11), 3955-3959 CODEN: MAMOBX; ISSN: 0024-9297
- American Chemical Society
- Journal

- LA English
- AB A terpolymer of poly(Bu acrylate) bearing terpyridine as well as oxetane units was synthesized by free radical polymerization and characterized using NMR, UV-vis, and GPC. Subsequently, UV-vis expts. indicated clearly a noncovalent crosslinking of the terpyridine moieties by addition of iron(II) ions. Moreover, the ability of covalent crosslinking was studied by polymerizing the oxetane rings utilizing Lewis acids. IR spectroscopy and DSC expts, clearly revealed the success of the combination of both steps when utilizing iron(II) ions and AlCl3.
- THERE ARE 53 CITED REFERENCES AVAILABLE FOR THIS RECORD RE.CNT 53 ALL CITATIONS AVAILABLE IN THE RE FORMAT
- T.3 ANSWER 17 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 2002:625102 CAPLUS
- DN 137:248043
- TI Atom transfer radical copolymerization (ATRCP) of a monomer bearing an oxetane group
- ΑU Singha, Nikhil K.; de Ruiter, Barteld; Schubert, Ulrich S.
- CS Lab. Macromolecular Organic Chem., Center Nanomaterials, Eindhoven Univ. Technology, Eindhoven, 5600 MB, Neth.
- Polymer Preprints (American Chemical Society, Division of Polymer Chemistry) (2002), 43(2), 165-166 CODEN: ACPPAY; ISSN: 0032-3934
- American Chemical Society, Division of Polymer Chemistry PB
- Journal; (computer optical disk)
- LA English
- AB The atom transfer radical polymerization of Me methacrylate with 3-ethyl-3-(acryloyloxymethyl)oxetane is described. Anal. of the copolymer confirmed that the oxetane ring did not open during polymerization
- RE.CNT 14 THERE ARE 14 CITED REFERENCES AVAILABLE FOR THIS RECORD ALL CITATIONS AVAILABLE IN THE RE FORMAT
- L3 ANSWER 18 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 2001:663120 CAPLUS
- DN 136:6399
- TI Synthesis and photochemical reaction of high performance UV curing oligomers
- AU Nishikubo, Tadatomi; Kameyama, Atsushi
- CS Department of Applied Chemistry, Faculty of Engineering, Kanagawa University, Kanagawa-ku, Yokohama, 221-8686, Japan
- Polymer Preprints (American Chemical Society, Division of Polymer SO Chemistry) (2001), 42(2), 722-723 CODEN: ACPPAY; ISSN: 0032-3934
- American Chemical Society, Division of Polymer Chemistry Journal; (computer optical disk) PB
- DT
- LA English
- AB Calixarene derivs. containing (meth)acrylate, vinyl ether, propargyl ether, oxetane, oxirane, or spiro ortho ester groups were synthesized by reaction of calixarenes with (meth)acrylic acid derivs., vinyl ether compds., propargyl bromide, oxetane derivs., epibromohydrin, and spiro ortho ester derivs. The caliwarene derivs. containing photoreactive groups had excellent thermal stability and high photochem. reactivity. The calixarene derivs. are of interest for UV curing systems, e.g., inks, coatings, solder masks, adhesives, and microelectronics uses.
- RE.CNT 11 THERE ARE 11 CITED REFERENCES AVAILABLE FOR THIS RECORD ALL CITATIONS AVAILABLE IN THE RE FORMAT

19990617 19990803 19990803 19990804

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L3 ANSWER 19 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
AN 2001:143711 CAPLUS
DN
     134:194666
    Actinic ray-curable sulfur-containing compositions with good curability
    and manufacture of coatings
IN Maruvama, Tsutomu
PA Kansai Paint Co., Ltd., Japan
SO
   Jpn. Kokai Tokkvo Koho, 7 pp.
    CODEN: JKXXAF
DT
    Patent
T.A
    Japanese
FAN.CNT 1
     PATENT NO.
                        KIND DATE
                                            APPLICATION NO.
                                                                     DATE
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                                             -----
PI JP 2001055507
PRAI JP 1999-232626
                         A 20010227
19990819
                                            JP 1999-232626
                                                                     19990819
     The compns. contain (A) 5-100 parts S-containing compds. manufactured by a
reaction
     of compds. (average mol. weight 150-1000) having ≥2 SH and compds. having
     1 acryloyl group and ≥2 alkoxysilyl groups and optional
     compds. having 1 acryloyl group and ≥1 epoxy groups
     and/or oxetane rings at acryloyl/SH molar ratio
     0.5-1.2, (B) 0-95 parts photochem. cationically reactive compds., and (C)
     0.05-20 parts photochem, cationic polymerization initiators. Thus, a
composition
     containing 100 parts reaction product of pentaerythritol
     tetrakis(mercaptoacetate) and 3-acryloxypropyl trimethoxysilane and 4
     parts CI 2758 (sulfonium salt-based initiator) was applied on a glass
     plate and cured by UV-irradiation to give a coating showing pencil hardness
L3
    ANSWER 20 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
AN
    1999:810952 CAPLUS
DN
    132:51248
    Photocurable hydrolyzed silane composition and photocured product
IN Sekiguchi, Manabu; Sugiyama, Naoki; Sato, Hozumi
PA
    Jsr Corp., Japan
SO
   Eur. Pat. Appl., 38 pp.
    CODEN: EPXXDW
DΨ
    Patent
LA
     English
FAN.CNT 1
                    KIND DATE APPLICATION NO. DATE
     PATENT NO.
                         ----
PI EP 965618
                         A1
                                19991222
                                            EP 1999-111732
                                                                   19990617
                          B1 20040102
     EP 965618
         R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT,
             IE, SI, LT, LV, FI, RO
    JP 200001648 A 20000107 JP 1998-170885
JP 2000026730 A 20000125 JP 1998-194817
W 482817 B 20020411 TW 1999-88110061
KR 2000006232 A 20000125 KR 1999-22643
US 6207728 B1 20010327 US 1999-335269
JP 2000109560 A 20000418 JP 1999-219938
JP 2000109694 A 20000418 JP 1999-220750
                                                                      19980618
                                                                     19980709
                                                                     19990616
                                                                     19990617
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PRAI JP 1998-170885 A 19980518
JP 1998-194817 A 19980709
JP 1998-220512 A 19980804
JP 1998-220513 A 19980804
JP 1998-220514 A 19980804
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AB Disclosed is a photo-curable composition comprising the following components (A) to (C): (A) hydrolyzable silane compound represented by the general formula (1) or a hydrolyzable silane compound represented by the general non-hydrolyzable organic group having 1 to 12 carbon atoms, X is a hydrolyzable group, and p is an integer of 0 to 3; (B) photo acid generator; and (C) dehydrating agent. By such constitution, it is possible to provide a photo-curable composition which has a rapid photo-curable rate, is excellent in characteristics such as storage stability, heat resistance, weather-ability, scratch resistance and the like, and is applicable to base materials having low heat resistance such as plastics, as well as a cured product obtained therefrom.

RE.CNT 3 THERE ARE 3 CITED REFERENCES AVAILABLE FOR THIS RECORD
ALL CITATIONS AVAILABLE IN THE RE FORMAT

```
L3 ANSWER 21 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
AN 1998:653719 CAPLUS
DN 129:276496
TI Hydrolyzable and polymerizable oxetanesilanes
IN Moszner, Norbert; Volkel, Thomas; Stein, Sabine; Rheinberger, Volker
PA 1VOCLAR A.-G., Liechtenstein
```

SO Eur. Pat. Appl., 21 pp.

CODEN: EPXXDW

DT Patent LA German

FAN.	CNT 1																	
	PATENT	NO.			KINI	)	DATE			API	PLI	CAT	ION :	NO.		D.	ATE	
						-												
PI	EP 8674	443			A2		1998	0930		ΕP	19	998-	2500	89		1	9980	313
	EP 8674	443			A3		2000	0628										
	EP 8674	443			B1		2003	0806										
	R:	AT,	BE,	CH,	DE,	DK,	ES,	FR,	GB,	GE	٦,	IT,	LI,	LU,	NL,	SE,	MC,	PT,
		IE,	SI,	LT,	LV,	FI,	RO											
	DE 1971	14324			A1		1998	1029		DE	19	97-	1971	4324		1	9970	325
	DE 1973	14324			B4		2004	0902										
	AT 2466	591			T		2003	0815		AT	19	998-	2500	89		1	9980	313
	CA 2232	2960			A1		1998	0925		CA	19	98-	2232	960		1	9980	324
	CA 2232	2960			C		2002	0129										
	JP 1033	30485			A		1998	1215		JP	19	998-	7759	3		1	9980	325
	US 6034	4151			A		2000	0307		US	19	98-	4759	2		1	9980	325
	US 6096	6903			A		2000	0801		US	19	98-	4765	9		1	9980	325
	US 6284	1898			B1		2001	0904		US	20	000-	5913	58		2	0000	609
PRAI	DE 1991	7-197	1432	4	A		1997	0325										
	US 1991	7-525	63P		P		1997	0715										
	US 1997	7-526	05P		P		1997	0715										
	US 1998	3-476	59		A3		1998	0325										

OS MARPAT 129:276496

ester, reaction of which with 3-(trimethoxysilyl)-1-propanethiol at room

AB The title compds., with specified structure, which can be polymerized at room temperature with very little shrinkage, are prepared Stirring 3-ethyl-3-(hydroxymethyl)oxetane with acryloyl

chloride in Et2O containing collidine at room temperature for 6 h gave 50% acrylate

temperature for 48 h gave 81% (3-ethyl-3-oxetanyl)methyl 3-[[3-(trimethoxysilyl)propyl)thio|propionate (I). Hydrolytic polymerization of an equimolar mixture of I and Me2Si(OMe)2 in refluxing BtOH gave a condensate which was used in a dental cement.

- L3 ANSWER 22 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 1997:579788 CAPLUS
- DN 127:235757
- TI Coating composition comprising a bicyclo- or spiro-orthoester-functional compound
- IN Van Den Berg, Keimpe Jan; Hobel, Klaus; Klinkenberg, Huig; Noomen, Arie; Van Oorschot, Josephus Christiaan
- PA Akzo Nobel N.V., Neth.
- SO PCT Int. Appl., 69 pp.
- CODEN: PIXXD2 DT Patent
- DT Patent
- LA English

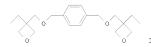
FAN.		1																	
			NO.			KIND DATE		APPLICATION NO.						D	ATE				
PI	WO					A1		1997	0828									9970:	
		W:						BA,											
								GE,											
								LV,											
								SI,											
		RW:																	
								PT,	SE,	BF,	B	J, I	CF,	CG,	CI,	CM,	GΑ,	GN,	ML,
						TD,													
	NL	1002 2247	427			C2		1997	0826		ИL	19	96-:	1002	427		1	9960:	223
	CA	2247	126			A1		1997	0828		CA	19	97-2	2247	126		1	9970:	221
	ΑU	9720 9701	930			A		1997	0910		ΑU	19	97-2	2093	0		1	9970:	221
	ZA	9701	542			A		1998	0727		ZA	19	97-:	1542			1	9970:	221
	EP	8821	06			A1		1998	1209		EP	19	97-	9061:	23		1	9970.	221
	EΡ	8821						2000											
		R:	AT, IE,		CH,	DE,	DK,	ES,	FR,	GB,	GE	٦,	IT,	LI,	LU,	NL,	SE,	MC,	PT,
	CN	1214	717			A		1999 2003	0421		CN	19	97-	1932	66		1	9970	221
	CN	1128	851			В		2003	1126										
	BR	9707	735			A		1999	0727		BR	19	97-	7735			1	9970:	221
	EP	9707 9420	51			A2		1999	0915		EP	19	99-2	2011	41		1	9970:	221
								ES,											
			IE,	FI															
	JP	2000 1953 2150 8821 6297 2180	5069	08		T		2000							18			9970:	
	AΤ	1953	31			T		2000	0815										
	ES	2150	758			Т3		2000			ES	19	97-	9061:	23		1	9970:	221
	PT	8821	06			T		2001			PΤ	19	97-	9061:	23		1	9970:	
	US	6297	329			B1		2001			US	19	97-8	8044	85 58 4		1	9970:	221
	RU	2180	674			C2		2002			RU	19	98-3	1175	58		1	9970:	221
	IN	1997	00AM	954		A		2006			ΙN	19	97-1	MA95	4		1	9970	506
								2001	0111		TW	19	97-8	8611	1273		1	9970	806
	NO	9803	859			A		1998	1020		NO	19	98-3	3859			1	9980	821
PRAI	ΑU	7549	19			В2		2002	1128		ΑU	20	00-	5651	3		2	0000	906
	GR	3034	728			Т3		2001	0131		GR	20	00-4	4024	17		2	0001	030
	US	2002	1611	35		A1		2002	1031		US	20	01-	9353	08		2	0010	822
	US	6593	479			В2		2003	0715										
PRAI	NL	1996	-100	2427		A		1996	0223										
	US	1996	-158	78P		P		1996	0422										

EP	1997-906123	A3	19970221
US	1997-804485	A3	19970221
WO	1997-EP892	W	19970221

AB A coating composition comprises a first compound of ≥1 bicyclo- or spiro-orthoester group and a second compound of ≥2 hydroxyl-reactive groups. The latent hydroxyl groups of the bicyclo- or spiro-orthoester groups have to be deblocked and reacted with the hydroxyl-reactive groups of the second compound to be cured. Bicyclo-orthoester compds, are made from the corresponding oxetane compound, as are polymers comprising ≥1 bicyclo- or spiro-orthoester group. Thus, Desmodur N 3390 was mixed with 1,4-diethyl-2,6,7-trioxabicyclo[2.2.2]octane in the presence of p-MeCGH4SO3H and Bu2Sn dilaurate in solvent and sprayed onto steel panels showing pot life >1 day and dry time 100 min.

- L3 ANSWER 23 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 1996:709842 CAPLUS
- DN 125:331792
- If Activation energy-curable coating compositions containing oxetane compounds with improved curability, gloss, adhesion, hardness, and crack resistance
- IN Niwa, Makoto; Oota, Hirovuki
- PA Toa Gosei Kk, Japan
- SO Jpn. Kokai Tokkyo Koho, 11 pp.
- CODEN: JKXXAF
- DT Patent
- LA Japanese
- FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE		
PI PRAI GI	JP 08239623 JP 1995-64801	A	19960917 19950228	JP 1995-64801	19950228		



- AB The coating compns. comprise compds. having 1-4 oxetane rings, cationic photopolymm. initiators, and optionally epoxides, vinyl ethers, and (meth)acryloyl compds. Thus, 100 parts compds. having 2 oxetane rings I and 4 parts diphenyl [p- (phenylthio)phenyl] sulfonium hexafluoroantimonate were stirred to give a composition, which was applied to a plywood and exposed to UV to give test pieces with JISA hardness 7, cross-cout adhesion 8-10, 990% in 60° gloss, pencil hardness 3H, and apprx.0 crack after thermal crack test (80° for 2 h. -20° for 2 h. repeated 2 times).
  - ANSWER 24 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 1996:705278 CAPLUS
- DN 125:331101
- II Actinic beam-curable adhesive compositions of oxetane compounds

- IN Niwa, Makoto; Oota, Hiroyuki
- PA Toa Gosei Kk, Japan
- SO Jpn. Kokai Tokkyo Koho, 12 pp. CODEN: JKXXAF
- DT Patent
- LA Japanese

FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE		
PI	JP 08231938	A	19960910	JP 1995-61898	19950224		
PRAI	JP 1995-61898		19950224				
AB	Adhesives for	bonding lami	inates with	improved peeling :	strength and sur		

Adhesives for bonding laminates with improved peeling strength and surface appearance contain compds. including 1-4 oxetane rings and photocationic polymerization initiators. Thus, 100 parts p-ROCH2C6H4CH2OR (R = 2-oxetanylbutyl) and 4 parts p-(Ph2S)SC6H4SPH+ SbF6- were mixed, applied on a biaxially drawn polypropylene (I) film, laminated with an undrawn I film (untreated on the surface), and irradiated with UV to give a test piece showing peeling strength ≥500 g/10 mm and good heat creep resistance.

- L3 ANSWER 25 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 1996:660747 CAPLUS
- DN 125:279010
- DN 125:2/9010
- Active energy-curable oxetane compositions for paper coatings with good gloss, adhesion, wear resistance, and flexibility
- IN Niwa, Makoto; Oota, Hiroyuki
- PA Toa Gosei Kk, Japan
- SO Jpn. Kokai Tokkyo Koho, 11 pp. CODEN: JKXXAF
- DT Patent
- LA Japanese
- FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE		
P.	I JP 08218296	A	19960827	JP 1995-50415	19950215		
	JP 3364915	B2	20030108				
PI	RAI JP 1995-50415		19950215				
G.	T						

AB The compnis comprise compds. having 1-4 oxetane rings, cationic photopolymn. initiators, and optionally epoxides, vinyl ethers, and (meth) acryloyl group-containing compds. Thus, a composition comprising 100 parts

a compound with 2 oxetane rings I and 4 parts an initiator II was applied to a paper and exposed to UV to give test pieces with JIS K 5400 cross-cut adhesion 8-10, no crack by bending test, >90% in 60° gloss, and steel wool abrasion resistance.

- ANSWER 26 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 1973:97399 CAPLUS
- DN 78:97399
- TI Reductive cleavage of polycyclic oxetanes
- ΑU Sauers, Ronald R.; Schinski, William; Mason, Marion M.; O'Hara, Elizabeth; Byrne, Bryan
- Sch. Chem., Rutgers State Univ., New Brunswick, NJ, USA SO Journal of Organic Chemistry (1973), 38(4), 642-6
- CODEN: JOCEAH; ISSN: 0022-3263 חת Journal
- LA English
- GI For diagram(s), see printed CA Issue.
- AB The action of H and catalysts, Li-ethylenediamine, Li-NH3, and alane on several polycyclic oxetanes (I, R = H, Ph, CH2Ph, α-naphthyl) is reported. In general, ring cleavages were effected which produced several novel alcs.
- ANSWER 27 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 1969:414144 CAPLUS
- DN 71:14144
- Oxetane copolymers
- IN Maloney, Daniel E. du Pont de Nemours, E. I., and Co. PA
- SO U.S., 4 pp.
- CODEN: USXXAM
- DΤ Patent
- LA English
- FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI	US 3440231	A	19690422	US 1967-610250	19670119
	FR 1551586	A	19681227	FR 1968-1551586	19680117
	NL 6800879	A	19680722	NL 1968-879	19680119
	GB 1154535	A	19690611	GB 1968-1154535	19680119
PRAI	US 1967-610250	A	19670119		

AB Acyl halide-α-olefin copolymers were treated with 3-amino- (I) or 3-hydroxyoxetane to give copolymers which were useful as coatings for decreasing the shrinking tendencies of proteinaceous and cellulosic substrates. Thus, 10 q. of a random ethylene (II)-methacryloyl chloride copolymer was prepared by reacting a chlorinating agent such as PC15 with an II-methacrylic acid copolymer, which was obtained by the process of Canadian Patent 655,298, and was dissolved in 450 ml. PhMe at 70°. Et3N (3.0 ml.) and 3.0 g. I were added to the solution and, after 30 min. at , the copolymer (III) was precipitated by adding excess Me2CO. A 2% III solution in perchloroethylene was padded onto 8-in. sqs. of cotton The Solution in Petermonographies was passed on the 9 in: Age, 51 separate populin, impregnated with 0.01-0.09 weight % Zn(BF4)2. The populin was heated 30 min. at 125°, then refluxed in PhMe. The amount of III on the fabric was reduced from 2.02 weight % to 0.88 weight % after refluxing 4 hrs., and to 0.82 weight %, after refluxing 8 hrs. An II-Et acrylateacryloyl chloride terpolymer was reacted similarly with I. The modified copolymer exhibited higher abrasion resistances than the unmodified copolymers and can be molded into weather-resistant films.

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ANSWER 28 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
AN
    1965:480121 CAPLUS
DM
     63:80121
OREF 63:14690h,14691a-b
    Bis(trifluoromethyl)ketene
ΑU
    England, D. C.; Krespan, C. G.
CS
    E. I. du Pont de Nemours & Co., Wilmington, DE
SO
    Journal of the American Chemical Society (1965), 87(17), 4019-20
    CODEN: JACSAT; ISSN: 0002-7863
DТ
    Journal
LA
    English
    CASREACT 63:80121
OS
GI
    For diagram(s), see printed CA Issue.
    Heating a mixture of (CF3) 2CHCO2H and excess P2O5 up to 250° pot
ΔB
     temps. gives over 90% (CF3)2C:C:O (I). I, b. 5°, and CF2:C(CF3)COF,
     b. 52°, are in equilibrium in the vapor phase over anionic catalysts
     such as NaF. Cycloaddn. to both the C:C and C:O groups of I can occur.
     Thus, I reacts with CH2: CHOBz at 100° to give 34% II and 42% III.
     Simple alkenes also add to I to form cyclobutanones and linear adducts. A
     condensed phase is necessary, so lower alkenes require higher pressures.
     A mixture obtained from I and C3H6 at 150° and 800 atmospheric, was separated
bv
     gas chromatography into .apprx.70% cyclobutanone derivative and 30%
     (CF3)2CHCOCH2CH:CH2. I reacts with trioxane in Et20 at 150° in the
     presence of ZnCl2 as catalyst to give IV, and with PhC.tplbond.CH at
     100° to give V. Ir data were given.
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     FILE 'CAPLUS' ENTERED AT 10:21:28 ON 27 APR 2007
L1
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L2
          11113 S ACRYLOYL
L3
             28 S L1 AND L2
=> s 11 and carbamate
         31159 CARBAMATE
            26 L1 AND CARBAMATE
=> s 14 and isocyanate
         66562 ISOCYANATE
1.5
             4 L4 AND ISOCYANATE
=> d 1-5 bib abs
'L-5' IS NOT A VALID FORMAT FOR FILE 'CAPLUS'
The following are valid formats:
ABS ----- GI and AB
ALL ----- BIB, AB, IND, RE
APPS ----- AI, PRAI
BIB ----- AN, plus Bibliographic Data and PI table (default)
CAN ----- List of CA abstract numbers without answer numbers
CBIB ----- AN, plus Compressed Bibliographic Data
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CLASS ----- IPC, NCL, ECLA, FTERM
DALL ----- ALL, delimited (end of each field identified)
DMAX ----- MAX, delimited for post-processing
FAM ----- AN, PI and PRAI in table, plus Patent Family data
FBIB ----- AN, BIB, plus Patent FAM
IND ----- Indexing data
IPC ----- International Patent Classifications
MAX ----- ALL, plus Patent FAM, RE
PATS ----- PI, SO
SAM ----- CC, SX, TI, ST, IT
SCAN ----- CC, SX, TI, ST, IT (random display, no answer numbers;
              SCAN must be entered on the same line as the DISPLAY,
              e.g., D SCAN or DISPLAY SCAN)
STD ----- BIB, CLASS
IABS ----- ABS, indented with text labels
IALL ----- ALL, indented with text labels
IBIB ----- BIB, indented with text labels IMAX ----- MAX, indented with text labels
ISTD ----- STD, indented with text labels
OBIB ----- AN, plus Bibliographic Data (original)
OIBIB ----- OBIB, indented with text labels
SBIB ----- BIB, no citations
SIBIB ----- IBIB, no citations
HIT ----- Fields containing hit terms
HITIND ----- IC, ICA, ICI, NCL, CC and index field (ST and IT)
              containing hit terms
HITRN ----- HIT RN and its text modification
HITSTR ----- HIT RN, its text modification, its CA index name, and
              its structure diagram
HITSEQ ----- HIT RN, its text modification, its CA index name, its
              structure diagram, plus NTE and SEQ fields
FHITSTR ----- First HIT RN, its text modification, its CA index name, and
              its structure diagram
FHITSEQ ---- First HIT RN, its text modification, its CA index name, its
             structure diagram, plus NTE and SEQ fields
KWIC ----- Hit term plus 20 words on either side
OCC ----- Number of occurrence of hit term and field in which it occurs
To display a particular field or fields, enter the display field
codes. For a list of the display field codes, enter HELP DFIELDS at
an arrow prompt (=>). Examples of formats include: TI; TI, AU; BIB, ST;
TI, IND; TI, SO. You may specify the format fields in any order and the information will be displayed in the same order as the format
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All of the formats (except for SAM, SCAN, HIT, HITIND, HITRN, HITSTR, FHITSTR, HITSEQ, FHITSEQ, KWIC, and OCC) may be used with DISPLAY ACC to view a specified Accession Number. ENTER DISPLAY FORMAT (BIB):1-5 bib abs hitstr

'1-5' IS NOT A VALID FORMAT FOR FILE 'CAPLUS'

specification.

The following are valid formats:

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ABS ----- GI and AB
ALL ----- BIB, AB, IND, RE
APPS ----- AI, PRAI
BIB ----- AN, plus Bibliographic Data and PI table (default)
CAN ----- List of CA abstract numbers without answer numbers
CBIB ----- AN, plus Compressed Bibliographic Data
CLASS ----- IPC, NCL, ECLA, FTERM
DALL ----- ALL, delimited (end of each field identified)
DMAX ----- MAX, delimited for post-processing
FAM ----- AN, PI and PRAI in table, plus Patent Family data
FBIB ----- AN, BIB, plus Patent FAM
IND ----- Indexing data
IPC ----- International Patent Classifications
MAX ----- ALL, plus Patent FAM, RE
PATS ----- PI, SO
SAM ----- CC, SX, TI, ST, IT
SCAN ----- CC, SX, TI, ST, IT (random display, no answer numbers;
             SCAN must be entered on the same line as the DISPLAY,
             e.g., D SCAN or DISPLAY SCAN)
STD ----- BIB, CLASS
IABS ----- ABS, indented with text labels
IALL ----- ALL, indented with text labels
IBIB ----- BIB, indented with text labels
IMAX ----- MAX, indented with text labels
ISTD ----- STD, indented with text labels
OBIB ----- AN, plus Bibliographic Data (original)
OIBIB ----- OBIB, indented with text labels
SBIB ----- BIB, no citations
SIBIB ----- IBIB, no citations
HIT ----- Fields containing hit terms
HITIND ----- IC, ICA, ICI, NCL, CC and index field (ST and IT)
             containing hit terms
HITRN ----- HIT RN and its text modification
HITSTR ----- HIT RN, its text modification, its CA index name, and
             its structure diagram
HITSEQ ----- HIT RN, its text modification, its CA index name, its
             structure diagram, plus NTE and SEQ fields
FHITSTR ---- First HIT RN, its text modification, its CA index name, and
             its structure diagram
FHITSEQ ---- First HIT RN, its text modification, its CA index name, its
             structure diagram, plus NTE and SEQ fields
KWIC ----- Hit term plus 20 words on either side
OCC ----- Number of occurrence of hit term and field in which it occurs
```

To display a particular field or fields, enter the display field codes, enter HELP DTELDS at an arrow prompt (\*>). Examples of formats include: T: TI,AU, BIB,ST; TI,IND; TI,SO. You may specify the format fields in any order and the information will be displayed in the same order as the format security.

All of the formats (except for SAM, SCAN, HIT, HITIND, HITRN, HITSTR, FHITSTR, HITSEQ, FHITSEQ, KWIC, and OCC) may be used with DISPLAY ACC

to view a specified Accession Number. ENTER DISPLAY FORMAT (BIB):bib abs

- ANSWER 1 OF 4 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 2006:54836 CAPLUS
- DN 144:128998
- Preparation of morpholinopyrimidines and related compounds as modulators TI of interleukin-12 (IL-12) production.
- IN Sun, Lijun; Demko, Zachary; Wada, Yumiko
- PA Synta Pharmaceuticals Corp., USA
- SO PCT Int. Appl., 81 pp.
- CODEN: PIXXD2 DT Patent

LA FAN.		glish 2																
	PA'	PENT	NO.			KIN		DATE			APPL					D	ATE	
PI		2006				A2					WO 2					2	0050	701
	WO	₩:	AE, CN, GE, LC, NG, SL, ZA, AT, IS, CF, GM,	AG, CO, GH, LK, NI, SM, ZM, BE, IT, CG, KE,	AL, CR, GM, LR, NO, SY, ZW BG, LT, CI, LS,	AM, CU, HR, LS, NZ, TJ, CH, LU, CM, MW,	AT, CZ, HU, LT, OM, TM, CY, GA, MZ,	AU, DE, ID, LU, PG, TN, CZ, MC, GN, NA,	AZ, DK, IL, LV, PH, TR, DE, NL, GQ,	DM, IN, MA, PL, TT, DK, PL, GW,	DZ, IS, MD, PT, TZ, EE, PT, ML,	EC, JP, MG, RO, UA, ES, RO, MR,	EE, KE, MK, RU, UG, FI, SE, NE,	EG, KG, MN, SC, US, FR, SI, SN,	ES, KM, MW, SD, UZ, GB, SK, TD,	FI, KP, MX, SE, VC, GR, TR,	GB, KR, MZ, SG, VN, HU, BF, BW,	GD, KZ, NA, SK, YU, IE, BJ, GH,
	KG, KZ, MD AU 2005262322 CA 2571178 US 2006063739 EP 1765325 R: AT, BE, BG IS, IT, LI				BG,	A1 A1 A1 A2 CH,	CY,	2006 2006 2006 2007 CZ,	0119 0323 0328 DE,	DK,	CA 2 US 2 EP 2 EE,	005- 005- 005- ES,	2571 1741 7678 FI,	178 73 34 FR,	GB,	2 2 2 GR,	0050 0050 0050	701 701 701
PRAI OS GI	WO	2004 2005 RPAT	-585 -US2	124P 3346		P		2004	0701	/	,	,	-2,	,	,			

AΒ Title compds. [I; R1 = N:CRaRb, NRc(CH2)nRc, cycloalkyl, aryl, heteroaryl; R2, R4 = Rc, halo, NO2, cyano, isothionitro, SRc, ORc; R2R4 = CO; R3 = Rc,

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alkenyl, alkynyl, ORc, O2CRc, SO2Rc, SORc, SRc, CORc, CO2Rc, etc.; R5 = H, alkyl; G = hydrazide, hydrazone, hydrazine, hydroxylamine, oxime, carbamate, thiocarbamate, guanidine, cyanoguanidine, urea, sulfamide, phosphoryl, Si(OH)2, CONRCCO, etc.; Y = bond, CH2, CO, C. NRc, O, S, SO, SO2, NRc, etc.; U, V = N, CRc; W = O, S, SO, SO2, NRc, NCORC; Ra, Rb = H, alkyl, aryl, heteroaryl; Rc = H, alkyl, aryl, heteroaryl, cyclyl, heteroaryl, etc.; n = 0-61, were prepared Thus, 3-[4-[N'-(3-methylbenzylidene)hydrazino]-6-morpholin-4-ylpyrimidin-2-yl]propani-ol (preparation given) was stirred with m-trifluoromethylphenyl carbamatic acid 3-[4-[N'-3]-aryl-proparation given) was stirred with m-trifluoromethylphenylcarbamatic acid 3-[4-[N'-3]-aryl-proparation given) was stirred with m-trifluoromethylphenylcarbamatic acid 3-[4-[N'-3]-6-morpholin-4-ylpyrimidin-2-yl]propyl ester. The latter inhibited II-12 production with an ICSO of <25 NM.
```

## => d 2-4 bib abs

- L5 ANSWER 2 OF 4 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 2004:964865 CAPLUS
- DN 141:395968
- TI Oxetane compounds containing styrenic functionality
- IN Musa, Osama M.
- PA National Starch and Chemical Investment Holding Corporation, USA
- SO U.S. Pat. Appl. Publ., 5 pp. CODEN: USXXCO
- DT Patent
- LA English
- EAN CNT 1

GΙ

PAN.							KIND DATE			APPLICATION NO.					DATE			
PI		2004		71		A1		2004			US 2	003-	4300	86		2	0030	506
	WO	2004	1015	41		A1		2004	1125		WO 2	004-	US12	489		2	0040	421
								AU,										
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			GE,	GH,	GM,	HR,	HU,	ID,	IL,	IN,	IS,	JP,	KE,	KG,	KP,	KR,	KZ,	LC,
								LV,										
								PL,										
	TJ, TM, Ti RW: BW, GH, Gi																	
		RW:																
								TJ,										
								CG,										
				TG	D.,	20,	O. ,	00,	O±,	011,	0117	OL1,	021	011,	112,	1111,	1111	D11,
	CN	1697				Α		2005	1116		CN 2	004-	8000	0440		2	0040	421
	EP	1620	417			A1		2006	0201		EP 2	004-	7608:	29		2	0040	421
		R:	ΑT,	BE,	CH,	DE,	DK,	ES,	FR,	GB,	GR,	IT,	LI,	LU,	NL,	SE,	MC,	PT,
								TR,										
								6 JP 2005-518201										
	CN 1944418																	
									US 2005-120585						2	1050	503	
PRAI	PRAI US 2003-430086 A CN 2004-80000440 A																	
WO 2004-US12489 W								2004	0-121									

AB The invention relates to compds. containing an oxetane functionality and a styrenic functionality having structure I; wherein Rl is a Me or Et group; R2 and R3 are H or a Me or Et group; R4 is a direct bond or a divalent hydrocarbon; X and Y are independently a direct bond or an ether, ester, amide, or carbamate group, provided both X and Y are not a direct bond; Q is a divalent hydrocarbon (which may contain heteroatoms of N, O, or S), and G is -ORI, -SR1, or -N(R2) (R3), in which R1, R2 and R 3 are as described above. The oxetane functionality is homopolymerizable in reactions that undergo cationic or anionic ring opening, and the styrenic is polymerizable with compds. such as electron acceptor compds. The dual functionality allows for dual cure processing. Thus, styrene carbamate Et oxetane was prepared from 3-ethyl-3-hydroxymethyl-oxetane and 3-isopropenyl-α, α-dimethyl-benzyl isocyanate (m-TMI).

RE.CNT 70 THERE ARE 70 CITED REFERENCES AVAILABLE FOR THIS RECORD
ALL CITATIONS AVAILABLE IN THE RE FORMAT

- L5 ANSWER 3 OF 4 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 1996:22563 CAPLUS
- DN 124:202752
- TI Heterocyclic lipids with PAF antagonist activities 4. Synthesis of 3,3-bis (hydroxymethyl)-oxetane, thietane and -azetidine, and 1,1-bis (hydroxymethyl) cycloalkane derivatives
- AU Chung, Sung-Kee; Ban, Su Ho; Kim, Byung Eog; Woo, Soon Hyung
- CS Dept. of Chemistry, Pohang Univ. of Science and Technology, Pohang, 790-784, S. Korea
- SO Korean Journal of Medicinal Chemistry (1995), 5(2), 94-111 CODEN: KJMCE7; ISSN: 1225-0058
- PB Korean Chemical Society
- DT Journal
- LA English
- GI

AB Conformationally constrained analogs of platelet activating factor incorporating a lipophile and a pyridine-like heterocycle coupled to core

groups such as 3,3-bis(hydroxymethyl)oxetanes I [X = 0, Rl = CONH (CH2)TMe, (CH2)15Me, COHH (CH2)15Me, R2 = H, CONHCH2-2-pyridinyl], -thictanes I [X = S, Rl = CONH (CH2)17Me, R2 = H, CONHCH2-2-pyridinyl], -azetidines I [X = Ndc, Rl = CONH (CH2)17Me, CONH (CH2)15Me, R2 = H, CONHCH2-2-pyridinyl], and 1,1-bis(hydroxymethyl)cycloalkanes I [X = (CH2)n, n = 1-4, Rl = CONH (CH2)17Me, CONH (CH2)15Me, R2 = H, CONHCH2-2-pyridinyl] through hydrogen bond accepting linkages such as ether, ester and carbamate have been synthesized as potent PAF receptor antagonists.

- L5 ANSWER 4 OF 4 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 1996:22562 CAPLUS
- DN 124:202751
- TI Heterocyclic lipids with PAF antagonist activities 3. Synthesis of 2,4-bis(hydroxymethyl)-oxetane and 1,3bis(hydroxymethyl)cyclobutane derivatives
- AU Chung, Sung-Kee; Ban, Su Ho; Woo, Soon Hyung
- CS Dep. of Chemistry, Pohang Univ. of Science and Technology, Pohang, 790-784, S. Korea
- SO Korean Journal of Medicinal Chemistry (1995), 5(2), 84-93
- CODEN: KJMCE7; ISSN: 1225-0058 PB Korean Chemical Society
- OT Journal
- LA English

Àc

AB Conformationally constrained analogs of platelet activating factor incorporating a lipophile and a pyridine-like heterocycle linked to core groups such as 2,4-bis(hydroxymethyl)oxetane, e.g. I, and 1,3-bis(hydroxymethyl)cyclobutane, e.g. II, via hydrogen bond acceptors such as carbamate and ether have been synthesized as potent PAF receptor antagonists.

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Executing the logoff script...

=> LOG H

COST IN U.S. DOLLARS SINCE FILE TOTAL ENTRY SESSION FULL ESTIMATED COST 110.35 110.56 DISCOUNT AMOUNTS (FOR QUALIFYING ACCOUNTS) SINCE FILE TOTAL ENTRY SESSION CA SUBSCRIBER PRICE -24.96 -24.96

SESSION WILL BE HELD FOR 120 MINUTES

STN INTERNATIONAL SESSION SUSPENDED AT 10:36:28 ON 27 APR 2007

Connecting via Winsock to STN

Welcome to STN International! Enter x:x

LOGINID:sssptau129rc

PASSWORD:

\* \* \* \* \* \* RECONNECTED TO STN INTERNATIONAL \* \* \* \* \* \* SESSION RESUMED IN FILE 'CAPLUS' AT 10:44:40 ON 27 APR 2007

FILE 'CAPLUS' ENTERED AT 10:44:40 ON 27 APR 2007 COPYRIGHT (C) 2007 AMERICAN CHEMICAL SOCIETY (ACS)

COST IN U.S. DOLLARS

COST IN U.S. DOLLARS SINCE FILE TOTAL
FULL ESTIMATED COST 110.35 110.35

DISCOUNT AMOUNTS (FOR QUALIFYING ACCOUNTS) SINCE FILE TOTAL

ENTRY SESSION
CA SUBSCRIBER PRICE -24.96 -24.96

=> d his

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(FILE 'HOME' ENTERED AT 10:21:10 ON 27 APR 2007)

FILE 'CAPLUS' ENTERED AT 10:21:28 ON 27 APR 2007

L1 4682 S OXETANE L2 11113 S ACRYLOYL

L3 28 S L1 AND L2

L4 26 S L1 AND CARBAMATE

L5 4 S L4 AND ISOCYANATE

=> d 15 1-4 bib abs

L5 ANSWER 1 OF 4 CAPLUS COPYRIGHT 2007 ACS on STN

AN 2006:54836 CAPLUS

DN 144:128998

```
TI Preparation of morpholinopyrimidines and related compounds as modulators of interleukin-12 (IL-12) production.
```

IN Sun, Lijun; Demko, Zachary; Wada, Yumiko

PA Synta Pharmaceuticals Corp., USA

SO PCT Int. Appl., 81 pp.

DT Patent LA English

FAN.CNT 2

PAN.			NO.							APPLICATION NO.						DATE			
PI		2006 2006								1	WO 2	005-1	J\$23	346		2	050	701	
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	RW: AT, BE, IS, IT, CF, CG, GM, KE,			BG, LT, CI, LS,	LU, CM, MW,	LV, GA, MZ,	MC, GN, NA,	NL, GQ,	PL, GW,	PT, ML,	RO, MR,	SE, NE,	SI, SN,	SK, TD,	TR, TG,	BF, BW,	BJ, GH,		
	AU 2005262322 CA 2571178 US 2006063739				A1 20060119 A1 20060323			AU 2005-262322 CA 2005-2571178 US 2005-174173 EP 2005-767834						20050701 20050701					
PRAI OS GI			LI,	LT,	LU,	MC, 2004	NL, 0701								HU,	IE,			

AB Title compds. [I R I = N:CRaBb, NRc (CH2) NRc, cycloalkyl, aryl, heteroaryl, R2, R4 = Rc, halo, NO2, cyano, isothionitro, SRc, ORc; R2R4 = CO; R3 = Rc, alkenyl, alkynyl, ORc, O2CRc, SOZRc, SORc, SRc, CORc, COZRc, etc.; R5 = H, alkyl; G = hydrazide, hydrazone, hydrazine, hydroxylamine, oxime, carbamate, thiocarbamate, guanidine, cyanoguandine, urea, sulfamide, phosphoryl, Si(OH)2, CONRCCO, etc.; Y = bond, CH2, CO, C:NRc, O, S, SO, SOZ, NRc, etc.; U, V = N, CRc; W = O, S, SO, SOZ, NRc, NCORc; Ra, Rb = H, alkyl, aryl, heteroaryl,

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cyclyl, heterocyclyl, etc.; n = 0-6], were prepared Thus,
3-[4-[N'-(3-methylbenzylidene)hydrazino]-6-morpholin-4-ylpyrimidin-2-
yl]propan-1-ol (preparation given) was stirred with m-trifluoromethylphenyl
isocyanate in MeCN containing cat. 4-dimethylaminopyridine to give
(3-trifluoromethylphenyl) carbamic acid 3-[4-[N'-(3-
methylbenzylidene)hydrazino]-6-morpholin-4-ylpyrimidin-2-ylpropyl ester.
The latter inhibited IL-12 production with an IC50 of <25 nM.
```

- ANSWER 2 OF 4 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 2004:964865 CAPLUS
- DN 141:395968
- TΙ Oxetane compounds containing styrenic functionality
- IN Musa, Osama M.
- PA National Starch and Chemical Investment Holding Corporation, USA SO U.S. Pat. Appl. Publ., 5 pp.
  - CODEN: USXXCO
- Patent DT LA
- English

FAN.	CNT	1																
		PENT I																
PI	US	2004	2250	71		A1		2004			US 2	003-	4300	86		2	0030	506
		6953																
	WO	2004	1015	41		A1		2004	1125		WO 2	004-	US12	489		2	0040	421
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			CN,	CO,	CR,	CU,	CZ,	DE,	DK,	DM,	DZ,	EC,	EE,	EG,	ES,	FI,	GB,	GD,
			GE, GH, GM, HR, HU, ID, IL, I			IN,	IS,	JP,	KE,	KG,	KP,	KR,	KZ,	LC,				
			LK,	LR,	LS,	LT,	LU,	LV,	MA,	MD,	MG,	MK,	MN,	MW,	MX,	MZ,	NA,	NI,
		NO, NZ, O			OM,	PG,	PH,	PL,	PT,	RO,	RU,	SC,	SD,	SE,	SG,	SK,	SL,	SY,
	TJ, TM, TN,																	
		RW:	BW,	GH,	GM,	KE,	LS,	MW,	MZ,	SD,	SL,	SZ,	TZ,	UG,	ZM,	ZW,	AM,	ΑZ,
								TJ,										
			ES,	FI,	FR,	GB,	GR,	HU,	IE,	IT,	LU,	MC,	NL,	PL,	PT,	RO,	SE,	SI,
			SK,	TR,	BF,	ВJ,	CF,	CG,	CI,	CM,	GΑ,	GN,	GQ,	GW,	ML,	MR,	ΝE,	SN,
			TD,															
						A 2005111								20040421				
	EΡ	1620	417			A1		2006	0201		EP 2	004-	7608	29		2	0040	421
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	JP	2006	5165	51		T		2006	0706	JP 2005-518201						2	0040	421
	CN 1944418 A				A		2007	0411	CN 2006-10153771						2	0040		
	US	2005 2003	1924	46		A1		2005	0901		US 2	005-	1205	85		2	0050	503
PRAI	US	2003	-430	086		A		2003	0506									
		2004																
	WO	2004	-US1	2489		W		2004	0421									
GI																		

AB The invention relates to compds. containing an oxetane functionality and a styrenic functionality having structure I, wherein R1 is a Me or Et group; R2 and R3 are H or a Me or Et group; R4 is a direct bond or a divalent hydrocarbon; X and Y are independently a direct bond or an ether, ester, amide, or carbamate group, provided both X and Y are not a direct bond; Q is a divalent hydrocarbon (which may contain heteroatoms of N, O, or S); and G is -OR1, -SR1, or -N(R2)(R3), in which R1, R2 and R 3 are as described above. The oxetane functionality is homopolymerizable in reactions that undergo cationic or anionic ring opening, and the styrenic is polymerizable with compds. such as electron acceptor compds. The dual functionality allows for dual cure processing. Thus, styrene carbamate Et oxetane was prepared from 3-ethyi-3-hydroxymethyl-oxetane and 3-isopropenyl-

 $\alpha, \alpha$ -dimethyl-benzyl isocyanate (m-TMI). RE.CNT 70 THERE ARE 70 CITED REFERENCES AVAILABLE FOR THIS RECORD

- L5 ANSWER 3 OF 4 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 1996:22563 CAPLUS
- DN 124:202752
- TI Heterocyclic lipids with PAF antagonist activities 4. Synthesis of 3,3-bis(hydroxymethyl)-oxetane, thietane and -azetidine, and 1,1-bis(hydroxymethyl)-oycloalkane derivatives

ALL CITATIONS AVAILABLE IN THE RE FORMAT

- AU Chung, Sung-Kee; Ban, Su Ho; Kim, Byung Eog; Woo, Soon Hyung
- CS Dept. of Chemistry, Pohang Univ. of Science and Technology, Pohang, 790-784, S. Korea
- SO Korean Journal of Medicinal Chemistry (1995), 5(2), 94-111 CODEN: KJMCE7; ISSN: 1225-0058
- PB Korean Chemical Society
- DT Journal
- LA English
- GI

AB Conformationally constrained analogs of platelet activating factor

incorporating a lipophile and a pyridine-like heterocycle coupled to core groups such as 3,3-bis(hydroxymethyl)oxetanes I [X = 0, Rl = CONH(CH2)17Me, (CH2)15Me, CONH(CH2)15Me, R2 = H, CONHCH2-2-pyridinyl], -thietanes I [X = S, Rl = CONH(CH2)17Me, R2 = H, CONHCH2-2-pyridinyl], -azetidines I [X = NAc, Rl = CONH(CH2)17Me, CONH(CH2)15Me, R2 = H, CONHCH2-2-pyridinyl], and 1,1-bis(hydroxymethyl)cycloalkanes I [X = (CH2)n, n = 1-4, Rl = CONH(CH2)17Me, CONH(CH2)15Me, R2 = H, CONHCH2-2-pyridinyl] through hydrogen bond accepting linkages such as ether, ester and carbamate have been synthesized as potent PAF receptor antagonists.

- L5 ANSWER 4 OF 4 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 1996:22562 CAPLUS
- DN 124:202751
- TI Heterocyclic lipids with PAF antagonist activities 3. Synthesis of 2,4-bis(hydroxymethyl)-oxetane and 1,3-bis(hydroxymethyl)cyclobutane derivatives
- AU Chung, Sung-Kee; Ban, Su Ho; Woo, Soon Hyung
- CS Dep. of Chemistry, Pohang Univ. of Science and Technology, Pohang, 790-784, S. Korea
- SO Korean Journal of Medicinal Chemistry (1995), 5(2), 84-93 CODEN: KJMCE7; ISSN: 1225-0058
- PB Korean Chemical Society
- DT Journal
- LA English
- GI

AB Conformationally constrained analogs of platelet activating factor incorporating a lipophile and a pyridine-like heterocycle linked to core groups such as 2,4-bis (hydroxymethyl) oxetane, e.g. I, and 1,3-bis (hydroxymethyl) cyclobutane, e.g. II, via hydrogen bond acceptors such as carbamate and ether have been synthesized as potent PAF receptor antagonists.

## => d 131:200264

ANSWER 1 CAPLUS COPYRIGHT 2007 ACS on STN

AN 131:200264 CAPLUS

TI Polyfunctional oxetane compounds as monomers and their manufacture

IN Kashima, Mikihito; Machida, Toshikazu

PA Ube Industries, Ltd., Japan

SO Jpn. Kokai Tokkvo Koho, 9 pp.

CODEN: JKXXAF

DT Patent

LA Japanese FAN.CNT 1

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
 JP 11246541 JP 1998-55172	A	19990914 19980306	JP 1998-55172	19980306

OS MARPAT 131:200264

=> FIL STNGUIDE

 COST IN U.S. DOLLARS
 SINCE FILE TOTAL ENTRY SESSION FULL ESTIMATED COST
 SINCE FILE TOTAL 125.88

DISCOUNT AMOUNTS (FOR QUALIFYING ACCOUNTS) SINCE FILE TOTAL ENTRY SESSION
CA SUBSCRIBER PRICE -28.08 -28.08 -28.08

FILE 'STNGUIDE' ENTERED AT 10:48:08 ON 27 APR 2007
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AND TECHNOLOGY CORPORATION, AND FACHINFORMATIONSZENTRUM KARLSRUHE

FILE CONTAINS CURRENT INFORMATION.
LAST RELOADED: Apr 20, 2007 (20070420/UP).

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YOU HAVE REQUESTED DATA FROM FILE 'CAPLUS' - CONTINUE? (Y) /N:v

L5 ANSWER 1 OF 4 CAPLUS COPYRIGHT 2007 ACS on STN GI

AB Title compds. [1; R] = N:CRaRb, NRc(CH2)nRc, cycloalkyl, aryl, heteroaryl; R2, R6 = Rc, halo, NO2, cyano, isothionitro, SRc, ORc; R2R4 = CO; R3 = Rc, alkenyl, alkynyl, ORc, OZCRc, SOZRc, SORc, SRc, CORc, COZRc, etc.; R5 = H, alkyl; G = hydrazide, hydrazone, hydrazine, hydroxylamine, oxime, carbamate, thiocarbamate, guanidine, cyanoguanidine, urea, sulfamide, phosphoryl, Si(OH12, CONRCCO, etc.; Y = bond, CH2, CO, C:NRc, O, S, SO, SO2, NRc, etc.; U, V = N, CRc; W = O, S, SO, SO2, NRc, NCORC; Ra, Rb = H, alkyl, aryl, heteroaryl; Rc = H, alkyl, aryl, heteroaryl, cyclyl, heterocyclyl, etc.; n = 0-6], were prepared Thus, 3-[4-[N¹-(3-methylbenzylidene)hydrazino]-6-morpholin-4-ylpyrimidin-2-yllpropan-1-ol (preparation given) was stirred with m-trifluoromethylphenyl isocyanate in McCN containing cat. 4-dimethylaminopyridine to give (3-trifluoromethylphenylparbamic acid 3-[4-[N¹-(3-methylbenylpidene)hydrazino]-6-morpholin-4-ylpyrimidin-2-yllpropyl ester. The latter inhibited II-12 production with an ICSO of <25 mM.

=> d 14 1-26 bib abs

YOU HAVE REQUESTED DATA FROM FILE 'CAPLUS' - CONTINUE? (Y) /N:y

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L4 ANSWER 1 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN
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AN 2006:97246 CAPLUS

DN 144:151546

TI Compositions containing oxetane compounds for use in

semiconductor packaging IN Musa, Osama M.

PA National Starch and Chemical Investment Holding Corporation, USA

SO Eur. Pat. Appl., 7 pp. CODEN: EPXXDW

DT Patent

LA English

FAN.	AN.CNT 1																		
	PA:	TENT :	NO.			KINI	D	DATE			APE	PLIC	ATI	I NOI	. OI		D	ATE	
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PI	ΕP	1621	534			A2		2006	0201		EΡ	200	5-1	1629	5		2	0050	727
	EΡ	1621	534			A3		2007	0124										
	R: AT, BE, (					DE,	DK,	ES,	FR,	GB,	GF	₹, I	Τ,	LI,	LU,	NL,	SE,	MC,	PT,
			IE,	SI,	LT,	LV,	FI,	RO,	MK,	CY,	ΑI	, T	R,	BG,	CZ,	EE,	HU,	PL,	SK,
			BA,	HR,	IS,	YU													
	US	2006	0255	42		A1		2006	0202		US	200	4-9	90163	31		2	0040	729
	JP	2006	0371	07		A		2006	0209		JP	200	5-2	21908	35		2	0050	728
	KR	2006	0488	70		A		2006	0518		KR	200	5-6	58962	2		2	0050	728
	CN	1743	373			A		2006	0308		CN	200	5-1	1010	9831		2	0050	729
PRAI	US	2004	-901	631		A		2004	0729										

AB Compns. containing oxetane compds. having ester, amide, urea,

carbamate, carbonate, or carbonyl functionality one C atom removed from the oxetane ring cure at high temps., and are suitable for use as underfill materials within a semiconductor package, particularly in applications using lead-free solder elec. interconnections. Thus, meterramethylxylene disocyanate (24.43 g, 0.1 mol) under N was mixed with 2 drops of Bu2Sn dilaurate catalyst heated to 60°, a-ethyl-3. (budroymethyloyetane (23.20 g, 0.2 mol) was added

3-ethyl-3-(hydroxymethyl)oxetane (23.20 g, 0.2 mol) was added over 20 min., then heated 4 h to give (after workup) a diurethane having m.p.  $71^\circ$ .

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L4
    ANSWER 2 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN
AN
    2006:54836 CAPLUS
    144:128998
    Preparation of morpholinopyrimidines and related compounds as modulators
    of interleukin-12 (IL-12) production.
    Sun, Lijun; Demko, Zachary; Wada, Yumiko
    Synta Pharmaceuticals Corp., USA
PA
    PCT Int. Appl., 81 pp.
SO
    CODEN: PIXXD2
    Patent
LA
    English
FAN.CNT 2
    PATENT NO.
                      KIND
                             DATE
                                       APPLICATION NO.
                                                             DATE
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    WO 2006007532
                       A2
                             20060119
                                       WO 2005-US23346
                                                              20050701
PΙ
    WO 2006007532
                       A3
                            20060817
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           ZA. ZM. ZW
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            CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG, BW, GH,
            GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW, AM, AZ, BY,
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                       A1
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    US 2006063739
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20070328

20040701

20050701

R: AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IS, IT, LI, LT, LU, MC, NL, PL, PT, RO, SE, SI, SK, TR

A2

P

747

EP 2005-767834

20050701

PRAI US 2004-585124P WO 2005-US23346 OS MARPAT 144:128998

GΙ

EP 1765325

AB Title compds. [I, Rl = N:CRaRb, NRc(CH2)RRc, cycloalkyl, aryl, heteroaryl, R2, R4 = Rc, halo, NO2, cyano, isothionitro, SRc, ORc; R2R4 = CO; R3 = Rc, alkenyl, alkynyl, ORc, O2CRc, SO2Rc, SORc, SRc, CORc, CO2Rc, etc.; R5 = H, alkyl; G = hydrazide, hydrazone, hydrazine, hydroxylamine, oxime, carbamate, thiocarbamate, guanidine, cyanoguandine, uras

sulfamide, phosphoryl, Si(OH)2, CONRCCO, etc.; Y = bond, CH2, CO, C:NRC, O, S, SO, SO2, NRC, etc.; U, V = N, CRC; W = O, S, SO, SO2, NRC, NCORC; Ra, Rb = H, alkyl, aryl, heteroaryl; Rc = H, alkyl, aryl, heteroaryl; Rc = H, alkyl, aryl, heteroaryl; Rc = 3.[4-[N^1-(3-methylbenzylidene) hydrazinol-6-mozpholin-4-ylpyrimidin-2-yllpropan-1-ol (preparation given) was stirred with m-trifluoromethylphenyl isocyanate in MeCN containing cat. 4-dimethylaminopyridine to give (3-trifluoromethylphenyl) carbamic acid 3-[4-[N^1-(3-methylbenzylidene) hydrazinol-6-mozpholin-4-ylpyrimidin-2-yllpropyl ester. The latter inhibited LI-12 production with an ICSO of <25 nM.

L4 ANSWER 3 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN

AN 2005:120921 CAPLUS

DN 142:219150

TI A preparation of 3-aminochroman and 2-aminotetralin derivatives, useful in the treatment of serotonin-mediated disorders

IN Hatzenbuhler, Nicole Theriault; Evrard, Deborah Ann; Mewshaw, Richard Eric; Zhou, Dahui; Shah, Uresh Shantilal; Inghrim, Jennifer Ann; Lenicek, Steven Edward; Baudy, Reinhardt Bernhard; Butera, John Anthony; Sabb, Annmarie L.; Failli, Amedeo Arturo; Ramamoorthy, Pudukkaraipudur Sivaramakrishna.

A Wyeth, John, and Brother Ltd., USA

SO PCT Int. Appl., 233 pp.

CODEN: PIXXD2

DT Patent LA English

LA Engli FAN.CNT 1

PATENT NO. KIND DATE DATE APPLICATION NO. ---------20050210 WO 2004-US24549 WO 2005012291 A1 W: AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NA, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW RW: BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW, AM, AZ, BY, KG, KZ, MD, RU, TJ, TM, AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IT, LU, MC, NL, PL, PT, RO, SE, SI, SK, TR, BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN. TD. TG US 2005032873 A1 20050210 US 2004-898866 20040726 20050210 AU 2004261649 A1 AU 2004-261649 20040729 CA 2533363 A1 20050210 CA 2004-2533363 20040729 EP 1651637 A1 20060503 EP 2004-779563 20040729 R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT, IE, SI, LT, LV, FI, RO, MK, CY, AL, TR, BG, CZ, EE, HU, PL, SK, HR BR 2004013022 Α 20061003 BR 2004-13022 20040729 CN 1860112 20061108 CN 2004-80028069 Α 20040729 20040729 JP 2007500718 20070118 JP 2006-522076 NO 2006000402 A IN 2006KN00387 A PRAI US 2003-491137P P 20060125 20060406 NO 2006-402 IN 2006-KN387 20060221 20070209 20030730 US 2003-491794P P 20030801 US 2004-898866 WO 2004-US24549 Α 20040726 W 20040729 OS MARPAT 142:219150

AB The invention relates to a preparation of 3-aminochroman and 2-aminotetralin derivs. of formula I [wherein: X is O or CH2; Rl is H, (cyclo)alkyl, or oxetane, etc.; R2 is (CH2)2-4-R5; R3 is OMe, C(O) (alkyl), or heterocycle, etc.; R4 is H or halogen; R5 is derivative of indole, benzothiophene, or benzofuran, etc.], useful in the treatment of serotonin-mediated disorders. The invention compals are useful for the treatment of serotonin-mediated disorders such as depression and anxiety. For instance, (indolylpropylamino)chroman derivative II (5-HI transporter affinity: Ki = 7 mM, 5-HIA function CAMP: ECSO = 228.5 mM) was prepared via N-alkylation of 3-amino-8-fluorochroman-5-carboxamide by 3-(3-bromopropyl)-5-fluor-lH-indole with a yield of 60%.

RE.CNT 6 THERE ARE 6 CITED REFERENCES AVAILABLE FOR THIS RECORD
ALL CITATIONS AVAILABLE IN THE RE FORMAT

- L4 ANSWER 4 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 2004:1068395 CAPLUS
- DN 142:155739
- TI Dimethylzinc-initiated radical reaction of cyclic ethers with arylamines, alkoxyamines, and dialkylhydrazines
- AU Yamamoto, Yasutomo; Maekawa, Masaru; Akindele, Tito; Yamada, Ken-Ichi; Tomioka, Kiyoshi
- CS Graduate School of Pharmaceutical Sciences, Kyoto University, Yoshida,
- Sakyo-ku, Kyoto, 606-8501, Japan SO Tetrahedron (2005), 61(2), 379-384 CODEN: TETRAB; ISSN: 0040-4020
- PB Elsevier B.V.
- DT Journal
- LA English
- OS CASREACT 142:155739
- AB Dimethylzinc-initiated radical reaction of THF with arylamines afforded

amino alcs, which were derived from the two mols, of THF and one mol, of an arylamine. The reaction seems to proceed via two-consecutive processes, electrophilic and then nucleophilic reactions of THF-derived species. Alkoxyamines and dialkylhydrazines reacted with electrophilic cyclic ether species to give the corresponding oximes and hydrazones of ω-hydroxyalkanal.

APPLICATION NO.

DATE

RE.CNT 28 THERE ARE 28 CITED REFERENCES AVAILABLE FOR THIS RECORD ALL CITATIONS AVAILABLE IN THE RE FORMAT

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ANSWER 5 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN
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AN 2004:1016091 CAPLUS

WO 2004101646

DN 142:7627

TТ Curable compositions containing hybrid oxetane compounds having electron acceptor or electron donor functionality

KIND DATE

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Musa, Osama M. TN

PA National Starch and Chemical Investment Holding Corporation, USA PCT Int. Appl., 23 pp. SO

CODEN: PIXXD2 DТ Patent

LA English

FAN.CNT 1	
PATENT	NO.

			CN,	CO,	CR,	CU,	CZ,	DE,	DK,	DM,	DZ,	EC,	EE,	EG,	ES,	FI,	GB,	GD,
			GE,	GH,	GM,	HR,	HU,	ID,	IL,	IN,	IS,	JP,	KE,	KG,	KP,	KR,	ΚZ,	LC,
			LK,	LR,	LS,	LT,	LU,	LV,	MA,	MD,	MG,	MK,	MN,	MW,	MX,	ΜZ,	NA,	NI,
			NO,	ΝZ,	OM,	PG,	PH,	PL,	PT,	RO,	RU,	SC,	SD,	SE,	SG,	SK,	SL,	SY,
			ТJ,	TM,	TN,	TR,	TT,	TZ,	UA,	UG,	US,	UZ,	VC,	VN,	YU,	ZA,	ZM,	ZW
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2004101646 A1 20041125 WO 2004-US12394 20040421 W: AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH,

curability and adhesion. THERE ARE 6 CITED REFERENCES AVAILABLE FOR THIS RECORD ALL CITATIONS AVAILABLE IN THE RE FORMAT RE.CNT 6

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ANSWER 6 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN
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2004:964868 CAPLUS

- DN 141:412014
- TI Adhesive and curable compositions containing hybrid oxetane
- compounds
- IN Musa, Osama M.
- PA USA
- SO U.S. Pat. Appl. Publ., 7 pp.
- CODEN: USXXCO
- DT Patent
- LA English
- FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI	US 2004225074	A1	20041111	US 2003-430089	20030506
	US 7034064	В2	20060425		
PR.	AI US 2003-430089		20030506		

GI

- AB Compns. for use as adhesives, coatings or encapsulants contain an oxetane functionality and an electron acceptor or an electron donor functionality, and can be represented by I in which RI = Me or Et; R2 is a divalent hydrocarbon; X and Y = direct bond, or an ether, ester, or carbamate functionality; Q is a divalent hydrocarbon, and E is an electron donor or electron acceptor functionality. Cinnamyl Et Oxetane was prepared from 3-ethyl-3-oxetane methanol and cinnamyl chloride. Similarly, maleinide oxetane derivs. were prepared and proved useful as epoxy substitutes in radically curable adhesive formulations.

  RE.CNT 69 THERE ARE 69 CITED REFERENCES AVAILABLE FOR THIS RECORD
- RE.CNT 69 THERE ARE 69 CITED REFERENCES AVAILABLE FOR THIS RECOL ALL CITATIONS AVAILABLE IN THE RE FORMAT
- L4 ANSWER 7 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 2004:964865 CAPLUS
- DN 141:395968
- TI Oxetane compounds containing styrenic functionality
- IN Musa, Osama M.
- PA National Starch and Chemical Investment Holding Corporation, USA
- SO U.S. Pat. Appl. Publ., 5 pp.
- CODEN: USXXCO
- DT Patent
- LA English
- DA ENGITS

PAN.	PENT	NO.			KIN	D	DATE		i	APPI	ICAT	ION :	NO.		D	ATE	
PI	2004 6953		71		A1 B2		2004		1	US 2	2003-	4300	86		2	0030	506
	2004		41		A1		2005		1	WO 2	2004-	US12	489		2	0040	421
	W:	AE,	AG,	AL,	AM,	AT,	AU,	AZ,	BA,	BB,	BG,	BR,	BW,	BY,	BZ,	CA,	CH,

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             LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NA, NI,
             NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SY,
             TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW
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             TD, TG
    CN 1697832
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PRAI US 2003-430086
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    CN 2004-80000440
                          A3
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    WO 2004-US12489
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                                20040421
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AB The invention relates to compds. containing an oxetane functionality and a styrenic functionality having structure I; wherein RI is a Me or Et group; R2 and R3 are H or a Me or Et group; R4 is a direct bond or a divalent hydrocarbon; X and Y are independently a direct bond or an ether, ester, amide, or carbamate group, provided both X and Y are not a direct bond; Q is a divalent hydrocarbon (which may contain heteroatoms of N, O, or S); and G is -oRl, -SRI, or -N(R2) (R3), in which R1, R2 and R 3 are as described above. The oxetane functionality is homopolymerizable in reactions that undergo cationic or anionic ring opening, and the styrenic is polymerizable with compds. such as electron acceptor compds. The dual functionality allows for dual cure processing. Thus, styrene carbamate Et oxetane was prepared from 3-ethyl-3-hydroxymethyl-oxetane and 3-isopropenyl-a,d-dimethyl-benzyl isocypane (m-TMI).

RE.CNT 70 THERE ARE 70 CITED REFERENCES AVAILABLE FOR THIS RECORD ALL CITATIONS AVAILABLE IN THE RE FORMAT

L4 ANSWER 8 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN

```
Oxetane compounds containing maleimide functionality
     Musa, Osama M.
PA
     National Starch and Chemical Investment Holding Corporation, USA
     U.S. Pat. Appl. Publ., 5 pp.
     CODEN: USXXCO
     Patent
LA
     English
FAN.CNT 1
     PATENT NO.
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                                              APPLICATION NO.
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PΙ
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             NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SY,
         TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW
RW: BW, GH, GM, KE, LS, MW, MZ, SD, SL, SZ, TZ, UG, ZM, ZW, AM, AZ,
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             ES, FI, FR, GB, GR, HU, IE, IT, LU, MC, NL, PL, PT, RO, SE, SI,
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     EP 1736473
                           A3
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             IT, LI, LU, MC, NL, PL, PT, RO, SE, SI, SK, TR
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     WO 2004-US12385
                                 20040421
                           TaT
OS
     MARPAT 141:395967
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2004:964864 CAPLUS

141:395967

AN DN

GΙ

AB The invention relates to compds. containing an oxetane functionality and a maleimide functionality having structure I; wherein R1 is a Me or Et group, R2 is a divalent hydrocarbon, X and Y independently are a direct bond, or an ether, ester, amide, or carbamate functionality, and

```
Q is a divalent organic group, and provided that X and Y will not both be
direct bonds.. The oxetane functionality is homopolymerizable
in reactions that undergo cationic or anionic ring opening, and the
maleimide functionality is homopolymerizable, or polymerizable with
compds. such as electron donor compds. The dual functionality allows for
dual cure processing. Thus, Et oxetane maleimide was prepared
from 6-maleimidocaproic acid and 3-ethyl-3-oxetane methanol in
the presence of 4-dimethylaminopyridine and 1,3-dicyclohexylcarbodiimide.
         THERE ARE 68 CITED REFERENCES AVAILABLE FOR THIS RECORD
         ALL CITATIONS AVAILABLE IN THE RE FORMAT
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T.4 ANSWER 9 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN

AN 2004:508879 CAPLUS

DN 141:54788

Oxetane compounds containing cinnamyl functionality

TΙ IN Musa, Osama M.

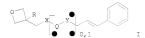
PA National Starch and Chemical Investment Holding Corporation, USA SO

U.S., 6 pp. CODEN: USXXAM

DT Patent

LA English

FAN.	CNT	1																
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PT		6252						2004									0030	
PI		6753																
		2004						2004			US 2	004-	7524	08		2	0040	106
		6943																
	WO	2004	1015	42		A1		2004	1125		WO 2	004-	US12	490		2	0040	421
		W:	ΑE,	AG,	AL,	AM,	AT,	AU,	AZ,	BA,	BB,	BG,	BR,	BW,	BY,	BZ,	CA,	CH,
			CN,	CO,	CR,	CU,	CZ,	DE,	DK,	DM,	DZ,	EC,	EE,	EG,	ES,	FI,	GB,	GD,
			GE,	GH,	GM,	HR,	HU,	ID,	IL,	IN,	IS,	JP,	KE,	KG,	KP,	KR,	KZ,	LC,
			LK.	LR.	LS.	LT.	LU.	LV,	MA.	MD.	MG.	MK.	MN.	MW.	MX.	MZ.	NA.	NI.
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		R:	ΑT,	BE,	CH,	DE,	DK,	ES,	FR,	GB,	GR,	IT,	LI,	LU,	NL,	SE,	MC,	PT,
			IE,	SI,				TR,										
		1791				A		2006	0621		CN 2	004-	8001	2027		2	0040	421
	JP	2007	5007	42		T		2007	0118		JP 2	006-	5324	54		2	0040	421
PRAI	US	2003	-430	114		A3		2003	0506									
		2004																
GI																		



AB These compds. contain an oxetame functionality and a cinnamyl functionality. The oxetame functionality is homopolymerizable in reactions that can undergo cationic or anionic ring opening, and the cinnamyl functionality is polymerizable with compds. such as electron acceptor compds. The dual functionality allows for dual cure processing. The generic structure of such compds. is I, in which R is a Me or Et group, X and Y independently are a direct bond, or an ether, ester, or carbamate group, and Q is a divalent hydrocarbon (which may contain heteroatoms of N, O, or S), provided that X and Y will not both be direct bonds in the same mol. Cinnamyl Et Oxetane was prepared from 3-ethyl-3-oxetane methanol and cinnamyl chloride.

RE.CNT 58 THERE ARE 58 CITED RETERENCES AVAILABLE FOR THIS RECORD

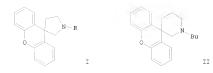
RE.CNT 58 THERE ARE 58 CITED REFERENCES AVAILABLE FOR THIS RECOR ALL CITATIONS AVAILABLE IN THE RE FORMAT

- L4 ANSWER 10 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 2004:97511 CAPLUS
- DN 140:147287
- TI Carbamic acid esters, base generators as curing agents, compositions reactive to bases, and applications of the compositions and their cured products
- IN Utsu, Hiromi; Toriumi, Suguru; Miki, Yasuaki
- PA Mitsubishi Chemical Corp., Japan
- SO Jpn. Kokai Tokkyo Koho, 11 pp.
- CODEN: JKXXAF
- DT Patent
- LA Japanese
- EAN CUT 1

FAN.	CIVI I					
	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE	
PRAI	JP 2004035413 JP 2002-190103 MARPAT 140:147287	A	20040205 20020628	JP 2002-190103	20020628	

AB The esters are I (R = n-valent organic group; n = 2-10; X = H, C1-10 hydrocarbyl, C1-10 alkoxy, halo; A and B may contain substituents). The compns., showing good curability, are useful for sealants and adhesives, and the cured products are useful for optical materials and laminates. Thus, a composition comprising 4,4'-bis(2-hydroxythio) diphenylsulfone dithioglycidyl ether and II was applied on a PET film and cured by UV irradiation to give a transparent layer.

- L4 ANSWER 11 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 2003:928777 CAPLUS
- DN 140:128262
- TI Synthesis of spiro[pyrrolidine or piperidine-3,9'-xanthenes] by anionic cycloacylation of carbamates
- AU Quintas, Domingo; Garcia, Alberto; Dominguez, Domingo
- CS Facultad de Química, Departamento de Química Organica y Unidad Asociada al CSIC, Universidad de Santiago de Compostela, Santiago de Compostela, 15782, Spain
- SO Tetrahedron Letters (2003), 44(52), 9291-9294 CODEN: TELEAY: ISSN: 0040-4039
- PB Elsevier Science B.V.
- DT Journal
- LA English
- OS CASREACT 140:128262
  - I



AB Xanthene spiropyrrolidines I (R = H, Ph(CH2)2, Bn, Bu) and spiropiperidine II were synthesized by a process in which the key step was intramol. trapping of a xanthen-9-yl anion by a carbamate side-chain situated at the same position.

RE.CNT 11 THERE ARE 11 CITED REFERENCES AVAILABLE FOR THIS RECORD
ALL CITATIONS AVAILABLE IN THE RE FORMAT

- L4 ANSWER 12 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 2001:490431 CAPLUS
- DN 135:256805
- TI The Paterno-Buechi reaction of  $\alpha$ -alkyl-substituted ene carbamates and benzaldehyde
- AU Bach, Thorsten; Schroder, Jurgen
- CS Technische Universitat Munchen, Lehrstuhl fur Organische Chemie I, Garching, 85747, Germany
- SO Synthesis (2001), (8), 1117-1124
- CODEN: SYNTBF; ISSN: 0039-7881
- PB Georg Thieme Verlag DT Journal
- LA English

AB

- OS CASREACT 135:256805
  - α-Substituted ene carbamates and enamides were prepared in two steps from the corresponding ketone, N-benzylamine and an appropriate acylating agent (Boc20, Ac20). The [2+2] photocycloaddn. reactions of benzaldehyde to alkenes which bear a primary or secondary alkyl substituent proceeded smoothly and gave 3-aminooxetanes in moderate to good yields (46-71%). An α-phenyl-substituted ene carbamate did not produce a photocycloaddn, product presumably due to rapid energy transfer (triplet sensitization) from the photoexcited aldehyde. For less obvious reasons a tert-butyl-substituted enamide did not react in the Paterno-Buechi reaction either. 3-Alkyl-3-aminooxetanes were obtained as a mixture of cisand trans-diastereoisomers. An increase in the steric bulk of the alkyl substituent R shifted the diastereomeric ratio (cis-8/trans-8) in the direction of the thermodynamically more stable cis-product (29:71 for R = CH3 up to 57:43 for R = cyclohexyl). Cis- and trans-oxetane diastereoisomers underwent a smooth ring opening/cyclization reaction upon treatment with trifluoroacetic acid. A trans-oxetane yielded oxazolidinones, and cis-oxetane gave exclusively a cis-oxazolidinone (54%). An was converted into a mixture of cis-(3-methyl-2-phenyl-3-oxetanyl) (phenylmethyl) carbamic acid 1,1-dimethylethyl ester (I) and trans-(3-methyl-2-phenyl-3oxetanyl) (phenylmethyl) carbamic acid 1,1-dimethylethyl ester (II). Thus, trans-II was converted into trans-4-(hydroxymethyl)-4-methyl-5-phenyl-3-(phenylmethyl)-2-oxazolidinone. And cis-I was converted into

cis-4-(Hydroxymethyl)-4-methyl-5-phenyl-3-(phenylmethyl)-2-oxazolidinone.

RE.CNT 43 THERE ARE 43 CITED REFERENCES AVAILABLE FOR THIS RECORD

ALL CITAGIONS AVAILABLE IN THE RE FORMAT

- L4 ANSWER 13 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 1999:494216 CAPLUS
- DN 131:242969
- FI Formation of 3-hydroxyalkyl carbamates from carbon dioxide, amines and
- AU Ishii, Shiqeru; Zhou, Ming; Yoshida, Yasuhiko; Noquchi, Hiromichi
- CS Department of Applied Chemistry, Faculty of Engineering, Toyo University, Saitama, 350-8585, Japan
- SO Synthetic Communications (1999), 29(18), 3207-3214 CODEN: SYNCAV; ISSN: 0039-7911
- PB Marcel Dekker, Inc.
- DT Journal
- LA English
- AB The reactions of carbon dioxide, primary or secondary aliphatic amines, and oxetanes at a CO2 pressure of 40 atm at 100-120°C without any catalysts afforded new monocarbamates of 1,3-propanediols, with concomitant formation of amino alcs. from oxetanes and amines.

RE.CNT 16 THERE ARE 16 CITED REFERENCES AVAILABLE FOR THIS RECORD
ALL CITATIONS AVAILABLE IN THE RE FORMAT

- L4 ANSWER 14 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 1997:522193 CAPLUS
- DN 127:207718
- TI Molecular mechanics versus volume additivity methods in prediction of energetic materials density. Comparative analysis, and improvements for
- solids and liquids
  AU Piacenza, G.; Jacob, G.; Graindorge, H.; Blaive, B.; Gallo, R.
- CS ENSSPICAM, Fac. Sciences Saint-Jerome, Marseille, F-13397, Fr.
- 50 International Annual Conference of ICT (1997), 28th(Combustion and Detonation), 123.1-123.14 CODEN: IACIEC, ISSN: 0722-4087
- PB Fraunhofer-Institut fuer Chemische Technologie
- DT Journal
- LA English
- AB A new method based on estns. of the mol. volume by Mol. Mechanics was used to approx. directly the d. of 142 solid and liquid energetic materials. Correlation analyses allowed to calculate the d. of these compds. with a mean error of 2.87%. The results showed a linear change with d. of the intermol. free space between the mols. The d. of the same energetic compds. was calculated by the commonly used volume additivity methods, and the estimated densities showed the same behavior as observed with Mol. Mechanics which appeared to be general and related to the structure of the solid and liquid materials. The results allowed to extend and improve the calcus. of the d. of these materials by the present available empirical procedures and to make a critical evaluation of their scope and limitations.
- L4 ANSWER 15 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 1996:22563 CAPLUS
- DN 124:202752
- TI Heterocyclic lipids with PAF antagonist activities 4. Synthesis of 3,3-bis(hydroxymethyl)-oxetane, -thietane and -azetidine, and 1,1-bis(hydroxymethyl)-oycloalkane derivatives
- AU Chung, Sung-Kee; Ban, Su Ho; Kim, Byung Eog; Woo, Soon Hyung

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CS Dept. of Chemistry, Pohang Univ. of Science and Technology, Pohang, 790-784, S. Korea
SO Korean Journal of Medicinal Chemistry (1995), 5(2), 94-111
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CODEN: KJMCE7; ISSN: 1225-0058

PB Korean Chemical Society

DT Journal LA English

LA GI

AB Conformationally constrained analogs of platelet activating factor incorporating a lipophile and a pyridine-like heterocycle coupled to core groups such as 3,3-bis(hydroxymethyl)oxetanes I [X = 0, Rl = CONH(CH2)17Me, (CH2)15Me, CONH(CH2)15Me, R2 = H, CONHCH2-2-pyridinyl], -thietanes I [X = S, Rl = CONH(CH2)17Me, R2 = H, CONHCH2-2-pyridinyl], -azetidines I [X = Nac, Rl = CONH(CH2)17Me, CONH(CH2)15Me, R2 = H, CONHCH2-2-pyridinyl], and 1,1-bis(hydroxymethyl)cycloalkanes I [X = (CH2)n, n = 1-4, Rl = CONH(CH2)17Me, CONH (CH2)15Me, R2 = H, CONHCH2-2-pyridinyl] through hydrogen bond accepting linkages such as ether, ester and carbamate have been synthesized as potent PAF receptor antagonists.

L4 ANSWER 16 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN

AN 1996:22562 CAPLUS

DN 124:202751

I Heterocyclic lipids with PAF antagonist activities 3. Synthesis of 2,4-bis(hydroxymethyl)-oxetane and 1,3bis(hydroxymethyl)cyclobutane derivatives

AU Chung, Sung-Kee; Ban, Su Ho; Woo, Soon Hyung

CS Dep. of Chemistry, Pohang Univ. of Science and Technology, Pohang, 790-784, S. Korea

SO Korean Journal of Medicinal Chemistry (1995), 5(2), 84-93 CODEN: KJMCE7; ISSN: 1225-0058

PB Korean Chemical Society

DT Journal

LA English

27

- Conformationally constrained analogs of platelet activating factor AB incorporating a lipophile and a pyridine-like heterocycle linked to core groups such as 2,4-bis(hydroxymethyl)oxetane, e.g. I, and 1,3-bis(hydroxymethyl)cyclobutane, e.g. II, via hydrogen bond acceptors such as carbamate and ether have been synthesized as potent PAF receptor antagonists.
- ANSWER 17 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN L4
- AN 1995:598395 CAPLUS
- DN 123:314308
- Synthesis and bioactivities of heterocyclic lipids as PAF antagonists, 2
- ΑU Chung, S. K.; Ban, S. H.; Kim, S. H.; Kim, B. E.; Woo, S. H.
- CS Dep. Chemistry, Pohang Univ. Science Technology, Pohang, 790-784, S. Korea
- SO Bioorganic & Medicinal Chemistry Letters (1995), 5(10), 1097-102
- CODEN: BMCLE8; ISSN: 0960-894X
- PB Elsevier
- DT Journal
- LA English

Conformationally constrained analogs of platelet activating factor (PAF) incorporating a lipophile and a pyridine-like heterocycle linked to core groups such as 1,1-bis(hydroxymethyl)cyclobutane and 2,4bis(hydroxymethyl)-oxetane, -thietane and -azetidine skeletons, e.g. I (X = 0, S, NAc, NBz), via hydrogen bond acceptors such as ether

and/or carbamate have been synthesized, and their in vitro and in vivo bioactivities have indicated potent and selective PAF antagonism.

- L4 ANSWER 18 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 1995:598394 CAPLUS
- DN 123:313592
- TI Synthesis and bio-activities of heterocyclic lipids as PAF antagonists.
- AU Chung, S. K.; Ban, S. H.; Kim, S. H.; Kim, B. E.; Woo, S. H.
- CS Dep. Chemistry, Pohang Univ. Science Technol., Pohang, 790-784, S. Korea
- SO Bioorganic & Medicinal Chemistry Letters (1995), 5(10), 1091-6
- CODEN: BMCLE8; ISSN: 0960-894X
- PB Elsevier DT Journal
- DT Journal LA English
- LA English GI
- X OCONHC18H37
- AB Conformationally constrained analogs of platelet activating factor (PAF) incorporating various combinations of a lipophile and a pyridine-like heterocycle via hydrogen bond acceptors such as ether and/or carbamate linked to a suitable core group such as 1.i-bis(hydroxymethyl)-cycloalkane and 3.3-bis(hydroxymethyl)-oxetane, thietane and -azetidine skeletons, e.g. I (X = 0, NAc, CH2), have been synthesized, and are shown to be powerful and selective
- L4 ANSWER 19 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 1989:153743 CAPLUS
- DN 110:153743
- TI Biscarbamoyl diselenide as a carbamoylating reagent. A convenient method for the preparation of ω-haloalkyl carbamates from cyclic ethers
- AU Fujiwara, Shinichi; Ogawa, Akiya; Kambe, Nobuaki; Ryu, Ilhyong; Sonoda, Noboru
- CS Fac. Eng., Osaka Univ., Suita, 565, Japan
- SO Chemistry Letters (1988), (10), 1805-6
- CODEN: CMLTAG; ISSN: 0366-7022

PAF receptor antagonists.

- DT Journal
- LA English
- OS CASREACT 110:153743
- AB Treatment of 4- to 7-membered cyclic ethers with Bt2NOSeSeCONEt2 and HgBr2 or HgGl2 resulted in carbamoylation-ring opening to give the corresponding \( \tilde{\text{main}} \) a-haloalkyl carbamates in moderate to high yields. E.g., tetrahydropyran with HgBr2 gave 44% \( \text{Bt2NCO} \) (CH2) 5Br and oxetane with HgBr2 gave 85% \( \text{EtNCO} \) (CH2) 3Br.
- L4 ANSWER 20 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 1967:500843 CAPLUS

- DN 67:100843
- TI Vulcanizable rubbery oxetane-epoxide copolymers
- IN Vandenberg, Edwin J. PA Hercules Inc.
- SO U.S., 8 pp.
- CODEN: USXXAM
- DT Patent
- LA English

FAN.CNT 1

FAN.	UNT I				
	PATENT NO.	KIND			DATE
PI AB	The title copolymer flexibility, solven low heat buildup. (I) 10, and trimeth and treated with a Et3Al in 3.2 parts part water during 3 and stirring the mi After 7.5 hrs. at 6 the reaction mixtur copolymer was colle 1% HGL, washed with 4,6'-thiobis (6-text at 80°C. to give a reduced sp. viscosi 100°C.) and contain separation of the e from work-up of the hr., with water unt neutral. The mixtu	t of U.s are pit t resist tresist tresist Thus, unylene ocatalyst heptane 0 min., x for the was dicted, was dicted, was dicted, was dicted, was districted with the tresist of the was districted with the tresist of the was districted with the was	s. 3,205,183 repared and atance, stabinder N, a mixide (II) 10 t prepared by cooling the adding 0.4; the polymeriz. The properties of the properties of the polymeriz. In the polymeriz of the polymerization of the pol	US 1962-220025 (see Brit. 980,093, are useful for their lity to heat, light, kture of toluene 73, parts was heated to y adding 7.2 parts Et a mixture to 0°C., a coart acetylacetone do 0°C. and 2 hrs. at 22 ation was stopped wif 4 vols. ether, and ar with ether and once with ether and once of the complete of the compl	19620828 CA 62: 7887h). low temperature and ozone, and epichlorohydrin 65°C. 220 to 0.92 part dding 0.072 lring 30 min., 6°C. 10. 8 parts EtOH, 10. 10. 10. 10. 10. 10. 10. 10. 10. 10. 10. 10. 10. 10. 10. 10. 10. 10. 10.
	ane to				

precipitate an 11% yield of copolymer which was separated, washed twice with heptane

and once with heptane containing 0.2% III, and dried in vacuo for 16 hrs. at  $80^{\circ}\mathrm{C}$ . The copolymer had reduced sp. viscosity 1 (0.1% in  $\alpha$ -chloronaphthalene), contained 45% I, and was a tough, snappy rubber. The ether-insol. copolymer (100 parts) was mixed with Bu3N 10, mercaptobenzothiazole 1.5, S 2, Z no 3, and stearic acid 2 parts and cured 40 min. at  $310^{\circ}\mathrm{F}$ . The cured polymer gave 97% gel and 600% swell in toluene (4 hrs. at 80°C.). The heptane-insol. copolymer (100 parts) was mixed with 2 parts hexamethylenediamine carbamate and cured 40 min. at  $310^{\circ}\mathrm{F}$ . The cured polymer gave 86% gel and 600% swell in toluene. I -3,3-dimethyloxetane copolymers, I-2-methyloxetane copolymers, and I-II-propylene oxide copolymers are prepared and vulcanized similarly.

- 4 ANSWER 21 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 1962:79308 CAPLUS
- DN 56:79308
- OREF 56:15451h-i,15452b-e
- TI Reactivity of oxetanes disubstituted in the 3-position by carrier radicals of functional groups. I. Reactions not affecting the heterocycle
- AU Chabrier, Pierre; Seyden-Penne, Jacqueline
- CS Fac. Med., Paris

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Bulletin de la Societe Chimique de France (1961) 2074-7
     CODEN: BSCFAS: ISSN: 0037-8968
     Journal
     Unavailable
LA
AB
     Substitution reactions in the 3-position using secondary amines,
     p-nitrobenzoates, tosylates, and carbamates with 3-(bromomethyl)-3-
     (hydroxymethyl)oxetane (I) are described and the resulting
     derivs, discussed. A benzene solution of I is heated with Me2NH in a sealed
     container 8 hrs. at 120° to yield 3-(dimethylaminomethyl)-3-
     (hydroxymethyl)oxetane (II), m. 62.4° (hexane), b12
111-13°; methobromide m. 201°. I in benzene is heated with
     piperidine in a sealed tube at 120° 8 hrs. to give
     3-(piperidinomethyl)-3-(hydroxymethyl)oxetane, b12
     151-5°, m. 38-9° (hexane). II kept with Ac20 in pyridine in
     the cold and then refluxed 2 hrs. gives 3-(dimethylaminomethyl)-3-(acetoxymethyl)oxetane, b18 127.9°; methobromide m.
     237°. The Williamson ether synthesis applied to I gives
     3-(aryloxymethyl)-3-(hydroxymethyl)oxetanes (III), which give
     p-nitrobenzoates (IV) with p-02NC6H4COCl in toluene at 0°
     piperidine (arvl and m.p. given): Ph. 104°; o-tolvl, 66°;
     O-MeOC6H4, 109-10°; o-ClC6H4, 80°; p-ClC6H4, 103°.

IV (aryl = Ph) with pyridine-HCl in anhydrous pyridine gives
     HOCH2(PhoCH2)C(CH2Cl)CH2O2CC6H4NO2-p (V), m. 80-1°. V and IV (arvl
     = Ph) both give, when treated with p-02NC6H4COCl,
     ClCH2(PhOCH2)C(CH2O2CC6H4NO2-p)2, m. 109°. III (aryl = Ph) and
     p-MeC6H4SO2Cl in toluene with pyridine give the tosylate, m. 95°.
     III treated cold with COC12 in toluene with pyridine and the intermediate
     chloride treated with NH3 in the cold give the following
     3-(aryloxymethyl)-3-(carbamoyloxymethyl)oxetanes(aryl and m.p. given):
     o-tolyl, 143°; o-MeOC6H4, 116°; o-ClC6H4, 139°;
     p-ClC6H4, 134-5°. Thus, under the conditions where the ethylene
     oxide ring and its derivs. such as epichlorohydrin and glycidic ethers are
     split, the 1,3-epoxide function of 3-(bromomethyl)-3-(hydroxymethyl)
     oxetane is stable. Nucleophilic reagents, e.g. amines or
     phenoxide ions, substitute for the Br atom while the OH group is easily
     esterified so as to be inactive in the presence of protons.
T.4
    ANSWER 22 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN
AN
     1962:60498 CAPLUS
DN
     56:60498
OREF 56:11529i,11530a
     Infrared spectra of oxetanes substituted in the 3,3-position by carrier
     radicals of functional groups
AU
     Guepet, Rene; Seyden-Penne, Jacqueline; Piganiol, Pierre; Chabrier, Pierre
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- CS
- Fac. Med., Paris so Bulletin de la Societe Chimique de France (1961) 2081-3
  - CODEN: BSCFAS; ISSN: 0037-8968
- DΤ Journal
- LA Unavailable
- AB An investigation is made of the IR spectra of 3,3-substituted derivs. of trimethylene oxide. The bands corresponding to the sym. and antisym. vibrations of the ring, affecting the C-O-C bond, have a constant frequency within the limits 960 to 980 cm.-1, regardless of the substituents on the ring.
- T.4 ANSWER 23 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN
- 1961:59205 CAPLUS

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DN 55:59205
OREF 55:11311e-i,11312a
TI Substituted 3-halo-1-propyl carbamates
IN Mooradian, Aram
PA Sterling Drug Inc.
DT
   Patent
LA
   Unavailable
FAN.CNT 1
                      KIND DATE
     PATENT NO.
                                       APPLICATION NO.
                        ----
PΙ
    GB 850003
                                19600928 GB 1959-14249
                                                                   19590427
AB
    The title compds., possessing central nervous system depressant activity,
     were prepared from substituted 3-halo-1-propanols. EtC(CH2OH)3 (135 g.) and
     158 g. pyridine was heated to reflux, treated dropwise with 238 g. SOC12,
     the mixture refluxed till gas evolution ceased, left overnight at room
     temperature, and dissolved in Et20. The Et20 solution was washed with H20 and
dilute
     aqueous HCl, dried, and distilled to give 89.6 g. (ClCH2)2C(CH2OH)Et (I), b27
     129°. Similarly prepared were: (ClCH2)2C(CH2OH)Me, b32 116-20°; Pr(ClCH2)C(CH2OH)Me (II), b23 104-8°;
     ClCH2C(CH2OH)Me2, b32 84-6°; (ClCH2)2C(CH2OH)Pr (III), b15 124-7°; ClCH2C(CH2OH)Et2, b11 95-100°;
     Me(CH2)4C(CH2C1)2CH2OH, b27 168-70°; and Me(ClCH2)C(CH2OH)Et, b100
     132-6°. I (17.1 g.) and 12.1 g. PhNMe2 in 50 ml. CHCl3 was added
     to 10 g. COC12 in 100 ml. PhMe at -10 to 0°, the solution left
     overnight at room temperature, saturated with NH3 gas, filtered, the filtrate
washed
     with dilute HCl, and evaporated to give 14 g. (ClCH2)2C(CH2OCONH2)Et, m.
     78-9° (n-pentane-C6H6). Similarly prepared were:
     (C1CH2)2C(CH2OCONH2)Me2, m. 75.5-8.5° (C6H6);
     Pr(ClCH2)C(CH2OCONH2)Me, m. 51-3° (n-pentane);
     C1CH2C(CH2OCONH2)Me2, m. 79-81.5° (C6H6);
     Me (CH2) 4C (CH2Cl) 2) CH2OCONH2, m. 65-7.5°; Me (C1CH2) C (CH2OCONH2) Et,
     m. 52.5-4.5° (n-hexane); and (C1CH2)3CCH2OCONH2, m. 58-60°
     (n-hexane). II (75.3 g.) and 11.5 g. Na in 750 ml. was refluxed 4 hrs.,
     filtered, and the filtrate distilled to give 43.5 g. 3-methyl-3-propyloxetane
     (IV), b. 139-40°. IV (11.4 g.) was slowly added to 10 g. HBr in
     250 ml. anhydrous Et20, the mixture left overnight, and distilled to give 16 g.
     Pr(BrCH2)C(CH2OH)Me, b13 106-7°. Similarly prepared was
     Pr(ICH2)C(CH2OH)Me, b11 118°. III (22.1 g.) and 14.6 g. PhNMe2 in
     45 ml. CHC13 was added dropwise to 12 g. COC12 in 120 ml. PhMe at
     0°, the solution allowed to warm to room temperature, left overnight, saturated
     with NH3, diluted with H2O, shaken with Et2O, the organic layer separated,
washed
     with dilute aqueous HCl, evaporated, the crystalline residue dissolved in Et20,
     decolorized with C. filtered, the filtrate partially evaporated, and treated
     with n-hexane to precipitate crystalline (ClCH2)2C(CH2OCONH2)Pr. m. 80-2°.
     Similarly prepared were: ClCH2C(CH2OCONH2)Et2, m. 91.5-4.0°
     (n-hexane); Pr(BrCH2)C(CH2OCONH2)Me, m. 58-60.5° (Et2O-hexane); and
     Pr(ICH2)C(CH2OCONH2)Me, m. 56-8° (n-hexane).
    ANSWER 24 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN
AN
    1961:27810 CAPLUS
    55:27810
DN
OREF 55:5450h-i,5451a
TI Reactivity of 3-aryloxymethyl-3-(hydroxymethyl)oxetanes
   Seyden-Penne, Jacqueline
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- CS Inst. pharmacol., Paris
- SO Compt. rend. (1960), 251, 1294-6
- DT Journal
- LA Unavailable
- GI For diagram(s), see printed CA Issue.
- AB O.CH2.CH2.C(CH2OH)CH2OAr (1) heated with dilute H2SO4 in the presence of p-dioxane gave (HCCH2)2CCH2OAr. With 25% HBr or concentrated HCl in heterogeneous phase or in aqueous dioxane, I gave (HCCH2)2C(CH2X)CH2OAr (II) (X = Cl or Br, resp.). I with cold absolute ECOH in the presence of H2SO4 gave II (X = OEt). The oxetane ring of I was attacked with secondary amines in the aqueous phase at 170° or above generally to form II (X = NR2). Secondary reactions occurred when the Ph was substituted. With Ar =  $\alpha$ -ClOH7, the product was (HCCH2)2C(CH2NMe2)2. The nucleophilic attack by phenoxide ion necessitated temps. above 175° and II (X = OAr) formed. The relative inertness of the oxetane ring in alkaline media permitted preparation of derivs. of the primary alc. (acetate, benzoate, p-nitrobenzoate, and carbamate) without altering the ring.
- L4 ANSWER 25 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 1957:51793 CAPLUS
- DN 51:51793
- OREF 51:9564a-h
- TI Oxetanes. VI. Reductive cleavage and substituent effects
- AU Searles, Scott, Jr.; Pollart, Kenneth A.; Lutz, Eugene F.
- CS Kansas State Coll., Manhattan
- SO Journal of the American Chemical Society (1957), 79, 948-51 CODEN: JACSAT: ISSN: 0002-7863
- DT Journal
- LA Unavailable
- OS CASREACT 51:51793
- AB cf. C.A. 49, 10174d. Cl(CH2)2COEt (241 q.) in 500 cc. Et20 reduced with 25 g. LiAlH4 in 700 cc. Et20 yielded 174 g. Cl(CH2)2CH(OH)Et (I), b25 82°, nD20 1.4435. I (174 g.) and 178 g. pyridine in 200 cc. CHCl3 treated with cooling with 173 g. AcCl, allowed to stand overnight, washed, and worked up gave 200 g. acetate (II) of I, b20 82-4°, nD20 1.4310. II (100 g.) added dropwise at 150° to 200 g. KOH, 200 g. NaOH, and 20 cc. H2O, the mixture heated to 170°, and treated with 50 cc. H2O, the gaseous product condensed in a cold trap, and the condensate dried with KOH pellets and distilled from Na gave 35.5 g. 2-ethyloxetane (III), b730 87°, nD20 1.4040, d. 0.850. Cl(CH2)2Ac treated with LiAlH4, and the mixture treated directly with 2 mole equivs. AcCl yielded 55% 2-methyloxetane (IV), b. 59°, nD20 1.3913. BrCH2CHMeCO2Me (125 g.) (obtained in 90% yield from dry HBr and CH2: CMeCO2Me) in 300 cc. Et20 treated with 20 g. LiAlH4 in Et20 gave 70.7 g. BrCH2CHMeCH2OH (V), b20 81-2°, nD20 1.4824; 3,5-dinitrobenzoate, m. 81° (from Et0H). Iso-BuOH was identified as a by-product. Accl (102 g.) added with stirring and cooling to 133 g. V in 104 g. pyridine and 150 cc. Et20 gave 157 g. acetate (VI) of V, b21 90-1°, nD20 1.4553. VI (151 g.) 15) g. accetate (VI) of V, DAL 30-1, HEAD 1,305. VI (AI) g., treated in the usual manner with caustic yielded 22,3 g. 3-methyloxetane (VII), b. 67°, nD20 1.3956. Cl(CH2)2COCl stirred 15 hrs. in the cold with AlCl3 in C6H6 gave 93% Cl(CH2)2R2 (VIII), m. 52°. VIII reduced in the usual manner with LiAlH4 gave 87% Cl(CH2)2CH(OH)Ph (IX), b0.03 75°, nD20 1.5412. IX (93.7 g.) in 65 g. pyridine and 100 cc. dry Et20 treated dropwise with 65 g. AcCl gave 95 g. acetate (X) of IX, b0.1 84-5°, nD20 1.5121. X (41 g.) added dropwise with stirring at 130° to 252 g. KOH in 100 cc. H2O, the mixture heated to  $170^\circ$

and treated with steam, the distillate extracted with Et2O, and the extract worked up gave 17.5 g. 2-phenyloxetane (XI), b0.5 52°, b8 87-8°, nD20 1.5288, d20 1.023. IX treated with hot alkali gave 58% pure XI. IV (15 g.) in 50 cc. Et20 added to 4.0 g. LiAlH4 in 100 cc. Et20, refluxed 3 hrs., hydrolyzed with 20% aqueous Na2CO3, and filtered, the filter cake washed with Et20, and the combined filtrate and washings distilled vielded 2 g. unchanged IV and 4.6 g. EtMeCHOH, b. 95-7°, nD20 1.3958 (3,5-dinitrobenzoate, m. 71-2°). A similar run in tetrahydrofuran refluxed 7 hrs. yielded 60% EtMeCHOH. A series of similar cleavage reactions with LiAlH4 and various oxetanes was carried out ( oxetane, resulting alc., % yield in 3-hr. run in Et20, % yield in 7-hr. run in tetrahydrofuran, b.p. and nD20 of alc., and m.p. of 3,5-dinitrobenzoate given): oxetane (XII), PrOH, 45, 65, 93-4°, -, 74°; III, Et2CHOH, 31, 56 (14 hrs.), 112°, 1.4104, 97°; VII, Me2CHCH2CH, -, 66, 106°, 1.3959, 86°; 2,3-dimethyloxetane (XIII), iso-PIMCCHOH, -, 58 (26 hrs.), 108-10°, 1.3972, 76°; 3-ethyl-2-propyloxetane (XIV), PrCH(OH) CHELMe, -, 72 (37 hrs.), b38 82-4°, 1.4235, 91-2°; 2,2-dimethyloxetane (XV) (b742 70°, nD20 1.3907), EtMe2COH, -, 55 (13 hrs.), 99-101°, 1.4020, -; XI, EtPhCHOH, 36, 70 (73% at 20 hrs.), b7 95°, 1.5255, - [N-(α-naphthyl)curbamate, m. 101°]; 3,3-dimethyloxetane, Me3CCH2OH, less than 5%, 32 (20 hrs.), 110-11° (m. 52°), - (N-phenyl-carbamate, m. 113-140; 3,3-diethyloxetane(XVI) (b. 138-40°, nD20 1.4230), BEZMECHEOH, -, 43 (40 hrs.), 156.5°, , (H tetrachlorophthalate, m. 146-7°); 2,2-diethyloxetane (XVII) (b. 124-6°, nD23 1.4168), Et3COH, -, 42, 136-8°, 1.4265, - (altophanate, m. 170°). XI (13.4 q.), 1.1 q. LiBH4, and 100 cc. Bu20 stirred 44 hrs. at 120-5° and processed in the usual manner yielded 5.5 q. EtPhCHOH and 4.1 q. unchanged XI. XII (4.5 g.) hydrogenated 3 hrs. at 150° over 2 g. Raney Ni and distilled gave 1.1 g. ProH, b735 93-4°, and 2.0 g. colorless liquid, b735 170° to b8 150°, possibly a mixture of CH2(CH2OH)2, H(OCH2CH2CH2)30H, etc.

L4 ANSWER 26 OF 26 CAPLUS COPYRIGHT 2007 ACS on STN

AN 1940:35946 CAPLUS DN 34:35946

OREF 34:5415b-c

- TI The amino derivatives of pentaerythritol. V. Trihydroxymonoaminotetramethy lmethane
- AU Govaert, F.; Beyaert, M.
- SO Proc. Acad. Sci. Amsterdam (1939), 42, 790-7
- DT Journal
- LA Unavailable
- AB 3,3-Di(hydroxymethyl)oxacyclobutane, m. 84°, b0.04 128°, was obtained in 81% yield by the action of KOH on monobromopentaerythritol. The ring was opened with aqueous NH3 at 200° with the formation of 60% of the monoamine, m. 207°. The tetra-Ac derivative, b0.04 173°, is a colorless very viscous liquid; the carbamate, (HOCH2) 3CCH2NHCOOH.H2NCH2C(H2OH)3, m. 149° (decomposition); the oxalate, (C5H1303N), 22.H2C204, m. 206°; and the picrate, C5H1303N, C6H2 (NO2) 30H, m. 98°.

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(FILE 'HOME' ENTERED AT 10:21:10 ON 27 APR 2007)

FILE 'CAPLUS' ENTERED AT 10:21:28 ON 27 APR 2007

L1 4682 S OXETANE L2 11113 S ACRYLOYL

L3 28 S L1 AND L2

L4 26 S L1 AND CARBAMATE 1.5 4 S L4 AND ISOCYANATE

FILE 'STNGUIDE' ENTERED AT 10:48:08 ON 27 APR 2007

FILE 'CAPLUS' ENTERED AT 10:51:10 ON 27 APR 2007

FILE 'STNGUIDE' ENTERED AT 10:51:10 ON 27 APR 2007

FILE 'CAPLUS' ENTERED AT 10:52:52 ON 27 APR 2007

FILE 'STNGUIDE' ENTERED AT 10:52:54 ON 27 APR 2007

FILE 'CAPLUS' ENTERED AT 10:59:08 ON 27 APR 2007

=> d 13 1-23 bib abs

ANSWER 1 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN 2007:116310 CAPLUS

- DN 146:172007
- TI Fabrication of optical members including index-different sections with variety of shape
- IN Koho, Satoshi; Eriyama, Yuichi
- Jsr Ltd., Japan SO
- Jpn. Kokai Tokkyo Koho, 17pp.
- CODEN: JKXXAF
- Patent LA Japanese

PA

FAN.CNT 1

P.A.N.	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI PRAI	JP 2007025091 JP 2005-205132	A	20070201 20050714	JP 2005-205132	20050714

AB The process involves these steps; applying compns. of (A) radical monomers, (B) radical initiators, (C) cationic polymerization monomers, and optionally (D) cationic photopolymn. initiators on supports, exposing the same to light in atmospheric containing ≥1 volume% O, and heating or exposing the same to light with different wavelength from that of the former, to form polymers of C around and/or upon the preformed polymers of A. The C polymers have smaller n than that of A polymers. Wavequides or microlens arrays can be manufactured as above without development stage.

- ANSWER 2 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN L.3
- AN 2006:1031534 CAPLUS
- DN 145:357658
- TI Thermally radical- and thermally cationic-curable vinyl polymer compositions with low viscosity and high mechanical strength

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- IN Tamai, Hitoshi; Nakagawa, Yoshiki
- PA Kaneka Corp., Japan
- SO Jpn. Kokai Tokkyo Koho, 44pp.
- CODEN: JKXXAF

PATENT NO.

\_\_\_\_\_

- DT Patent
- T.A Japanese
- FAN.CNT 1

PI	JP 2006265483	A	20061005	JP 2005-89220	20050325
PRAI	JP 2005-89220		20050325		
AB	The compns., useful	for sea	als and gask	ets, comprise vinyl po.	lymers having
	≥2 O2CCRa:CH2 (I; Ra	a = H,	C1-20 organi	c group) in a mol. cont	taining
	≥1 I at end groups a	and epo:	xides and/or	oxetane compds.	
	Thus, a composition	compri:	sing acryloy.	l-terminated Bu acrylat	te-Et
	acrylate-2-methoxyet	thyl ac	rylate copol;	ymer manufactured by 1:	iving atom transfer
	radical polymerizat:	ion (AT	RP) in the p	resence of CuBr 70, bea	nzoperoxide (Nyper
	BW) 0.7, 3,4-epoxyc	ylohexy.	lmethyl 3,4-	epoxycylohexanecarboxy:	late
	(Celloxide 2021P) 30	, then	mally cation.	ic polymerization catal	lyst of
	(2-butenvl)tetrameth	nylenes	ulfonium hex	afluoroantimonate (Adel	ka Opton CP

77) 0.45 part was hot-pressed into a sheet showing 30% modulus (JIS K 6301) 0.22 MPa, strength at break 1.42 MPa, and elongation at break 115%.

KIND DATE APPLICATION NO. DATE

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- ANSWER 3 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN L3
- 2006:489898 CAPLUS AN
- 145:9782 DN
- Coating compositions with good scratch, acid, and solvent resistance for automobile bodies
- IN Maeda, Shinichi; Saito, Yoshikazu; Toyama, Masayuki; Hayama, Yasushi

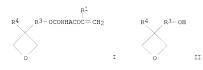
- PA Mitsubishi Rayon Co., Ltd., Japan
- SO Jpn. Kokai Tokkvo Koho, 28 pp.
- CODEN: JKXXAF
- Patent T.A Japanese
- FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI	JP 2006131670	A	20060525	JP 2004-319366	20041102
PRAI	JP 2004-319366		20041102		

- PRAI JP 2004-319366
- Title coating compns. comprise (A) a compound having a (meth) acryloyl group and an anhydride group formed by at least two carboxylic acid groups or one ester group and a carboxylic acid group, an acrylic copolymer having at least an epoxy group or an oxetane group, and a radical polymerization initiator. Thus, styrene 20, tridecyl methacrylate 15, glycidyl methacrylate 45, and 4-hydroxybutyl acrylate were polymerized to give a copolymer with epoxy equivalent 315 q/equiv and
- weight average mol. weight 5000, 315 parts of which was mixed with 2-acryloyloxy trimellitic anhydride obtained from 2-hydroxyethyl acrylate and trimellitic anhydride 283, 1-hydroxycyclohexylphenylketone 18, Sanol LS 765 12, tetraethylphosphonium bromide 6, and Modaflow 1.2 parts, applied on a coated steel plate, dried at 160° for 30 min, and irradiated with a UV ray to give a test piece, showing good acid, solvent, and scratch resistance, and gloss retention, and pencil hardness F.
- L3 ANSWER 4 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- 2006:199643 CAPLUS AN
- DN 145:505777
- TI Development of high performance photo-curable polymers and oligomers using novel reactions of oxetane compounds
- AU Nishikubo, Tadatomi; Kameyama, Atsushi
- CS Department of Applied Chemistry, Faculty of Engineering, Japan
- SO RadTech Europe 05: UV/EB--Join the Winning Technology, [Conference Proceedings], Barcelona, Spain, Oct. 18-20, 2005 (2005), Volume 2, 43-47 Publisher: RadTech Europe Association, The Haque, Neth. CODEN: 69HVYN
- DT Conference; General Review
- LA English
- A review. The authors recently found many new addition reactions of oxetanes with certain reagents such as phenols and carboxylic acids using certain quaternary onium salts or crown ether complexes as catalysts. More recently, we also found new anionic ring-opening polymerization of oxetanes containing pendant hydroxyl groups and alternating anionic ring-opening copolymn. of oxetanes with cyclic carboxylic anhydrides using appropriate catalyst system. These reactions have been widely applied to the synthesis of polymers and thermo-setting reactions of oxetane resins. In this paper, we would like to introduce the application of these new reactions for the synthesis of high performance photo-curable polymers and oligomers containing pendant or terminal (meth)acryloyl groups. The authors also report the photochem, property of the resulting polymers and oligomers. Furthermore, the authors would like to talk about the synthesis of certain calixarenes and poly(imide)s containing oxetane groups as high performance materials and their photochem. reaction.
- RE.CNT 15 THERE ARE 15 CITED REFERENCES AVAILABLE FOR THIS RECORD ALL CITATIONS AVAILABLE IN THE RE FORMAT

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L3
     ANSWER 5 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
AN
     2005:1075860 CAPLUS
DN
     143:368070
     Photoradically/photocationically curable compositions with low viscosity
     Okada, Kenji; Nakagawa, Yoshiki
     Kaneka Corporation, Japan
PA
SO
     PCT Int. Appl., 65 pp.
     CODEN: PIXXD2
     Patent
LA
     Japanese
FAN.CNT 1
     PATENT NO.
                          KIND
                                  DATE
                                               APPLICATION NO.
                                                                        DATE
                           ----
                                               -----
     WO 2005092981
                           A1
                                   20051006 WO 2005-JP5510
                                                                        20050325
PT
         W: AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH,
              CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MM, MX, MZ, NA, NT, MR
              NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SM,
         SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW RW: BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW, AM,
              AZ, BY, KG, KZ, MD, RU, TJ, TM, AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IS, IT, LT, LU, MC, NL, PL, PT,
              RO, SE, SI, SK, TR, BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML,
              MR, NE, SN, TD, TG
     CA 2561169
                            A1
                                   20051006
                                             CA 2005-2561169
                                                                         20050325
                           A1
     EP 1728826
                                  20061206
                                               EP 2005-727009
                                                                         20050325
         R: AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE,
              IS, IT, LI, LT, LU, MC, NL, PL, PT, RO, SE, SI, SK, TR
     CN 1938377
                                  20070328
                                                CN 2005-80009881
                           A
PRAI JP 2004-92556
                            Α
                                   20040326
     WO 2005-JP5510
                           W
                                   20050325
AB
     Title compns. comprise (A)≥2 acryloyl group-containing vinyl
     polymers (≥1 acryloyl group is a terminal group), (B)
     epoxy compds. and.or oxetane compds., (C) photoradical
     initiators, and (D) photocationic initiators. Thus, Bu acrylate, Et
     acrylate, and 2-methoxyethyl acrylate were polymerized in the presence of
     copper (I) bromide, pentamethyldiethylenetriamine, and di-Et
     2,5-dibromoadipate, potassium acrylate was added therein and reacted to
     give acryloyl-terminated copolymer with number average mol. weight 16,900
     and polydispersity 1.14, 100 parts of which was mixed with
     2,2-diethoxyacetophenone 0.2, Epolite 4000 30, Adeka Optomer SP 172 1.5,
     and Irganox 1010 1 parts to give a composition with viscosity 150 Pa-s at
     23°, which was cured by irradiation to give a cured product, showing
     30% modulus 0.52 MPa, tensile strength at break 0.94 MPa, and elongation
     at break 52%.
RE.CNT 9
               THERE ARE 9 CITED REFERENCES AVAILABLE FOR THIS RECORD
               ALL CITATIONS AVAILABLE IN THE RE FORMAT
L3
     ANSWER 6 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
     2005:823679 CAPLUS
AN
     143:212295
     Preparation of polymerizable (meth)acryloyl group-containing
     oxetane monomers
IN
     Kamata, Hirotoshi; Morinaka, Katsutoshi; Uchida, Hiroshi
     Showa Denko K.K., Japan
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PCT Int. Appl., 21 pp.
     CODEN: PIXXD2
     Patent.
LA
     English
FAN.CNT 1
     PATENT NO.
                         KIND
                                DATE
                                           APPLICATION NO.
                         ----
     WO 2005075445
                                20050818 WO 2005-JP2381
                         A2
                                                                   20050209
        W: AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH,
             CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD,
             GE, GH, GM, HR, HU, ID, IL, IN, IS, KE, KG, KP, KR, KZ, LC, LK,
             LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NA, NI, NO,
             NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SY, TJ,
             TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW
         RW: BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW, AM,
             AZ, BY, KG, KZ, MD, RU, TJ, TM, AT, BE, BG, CH, CY, CZ, DE, DK,
             EE, ES, FI, FR, GB, GR, HU, IE, IS, IT, LT, LU, MC, NL, PL, PT,
             RO, SE, SI, SK, TR, BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML,
             MR, NE, SN, TD, TG
     JP 2005255671
                          Α
                                20050922
                                            JP 2005-24723
     EP 1713787
                          A2
                                20061025
                                            EP 2005-710281
                                                                   20050209
         R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT,
             IE, SI, LT, LV, FI, RO, MK, CY, AL, TR, BG, CZ, EE, HU, PL, SK,
             BA, HR, IS, YU
     US 2007060760
                                20070315
                                            US 2006-588072
                         A1
                                                                   20060731
PRAI JP 2004-32867
                                20040210
                          Α
     US 2004-545488P
                         Ρ
                                20040219
     WO 2005-JP2381
                         W
                                20050209
OS
    MARPAT 143:212295
GI
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AB Polymerizable (meth)acryloyl group-containing oxetane [I; A = ORZ, direct bond; R2 = divalent hydrocarbyl (which may contain an oxygen atom in the main chain); R1 = H, CH3; R3 = C1-6 (un)branched alkylene; R4 = C1-6 (un)branched alkyl) monomers are prepared in high yield and selectivity by the addition reaction of (meth)acrylate isocvanates H2C:C(R1)CO(A)NCO with 3-(hydroxyalkyl)-substituted oxetanes (II) in the presence of a tertiary amine or tin-compound catalyst. Thus, 2-acryloyloxyethyl isocyanate was mixed in Et acetate containing dibutyltin dilaurate and reacted with 3-ethyl-3-(hydroxymethyl)oxetane, producing an oxetanyl group-containing methacrylate ester monomer (III).

ANSWER 7 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN L3

AN 2005:428262 CAPLUS

DN 142:482780

TI Electrically conductive polymers containing condensed indoline rings and their manufacture

ΤN Kodera, Tatsuva

Mitsubishi Paper Mills, Ltd., Japan PA

Jpn. Kokai Tokkyo Koho, 28 pp.

CODEN: JKXXAF DT Patent

LA Japanese

FAN.CNT 1

SO

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE		
PI PRAI	JP 2005126493 JP 2003-361092	A	20050519 20031021	JP 2003-361092	20031021		

$$\begin{array}{c} & \text{CH=CH-Ar2 O-C-C=CH2} \\ & \text{Z3} \\ & \text{N} \\ & \text{R10} \end{array}$$

- The manufacturing method of polymers, useful for electrophotog, photoreceptors, AB electroluminescent devices, etc., includes polymerizing I (R10 = alkyl, aryl, heterocyclic; R11 = H, amino, alkyl, alkoxy; R12 = H, alkyl; Ar2 = divalent group; Z3 = group forming saturated C5-8 ring). Manufacturing method including polymerizing mixts. of I and XCH2(OCH2CH2)mO2CC:CH2R2 (II; X= 3-R1-3-oxetanyl; R1,2 = H, alkyl; m = 0-2) are also claimed. Thus, I (R10 = Ph, R11 = H, R12 = Me, Ar2 = phenylene, Z3 = cyclopentane) and II (X= 3-R1-3-oxetanyl; R1 = Et, R2 = Me, m = 0) were polymerized in the presence of AIBN to give a copolymer with Mn 63,000 and Mw 92,000. A multilayer photoreceptor containing charge-transporting layer comprising the copolymer showed electrostatic potential -600 V at applied voltage -6 kV and light exposure for decreasing the potential in half (E1/2) 1.0 lx-s.
- L3 ANSWER 8 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN

```
AN 2005:155387 CAPLUS
DN 142:246263
TI Dental adhesive composition
IN Anzai, Misaki; Kawaquchi, Motoki
PA Dentsply-Sankin K. K., Japan
SO Eur. Pat. Appl., 13 pp.
    CODEN: EPXXDW
    Patent
T.Z
    English
FAN.CNT 1
    PATENT NO.
                      KIND DATE APPLICATION NO.
                                                             DATE
                             20050223 EP 2004-19518
PΤ
   EP 1508321
                       A1
                                                               20040817
        R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT,
            IE, SI, LT, LV, FI, RO, MK, CY, AL, TR, BG, CZ, EE, HU, PL, SK, HR
    JP 2005065902
                            20050317 JP 2003-298363
                       A
                                                               20030822
    US 2005054749
                        A1
                              20050310
                                         US 2004-920358
                                                                20040818
                            20030822
PRAI JP 2003-298363
                       A
    A dental adhesive composition which can quickly be hardened even in the
    presence of oxygen without using a radical generating agent such as a
    peroxide or a photopolymn. initiator, to give high bond strength,
    comprises a carboxylic acid having a (meth)acryloyl group and a
    carboxyl group, both of which are attached to an aromatic ring; a bisphenol A
    derivative having 2 (meth)acryloyl groups; a hydroxylalkyl
    (meth)acrylate; a (meth)acrylate derivative having an acid group; and at least
    one polymerization initiator selected from the group consisting of aromatic
amines,
    aliphatic amines, and aromatic sulfinic acids, the composition being
substantially
    free from any radical polymerization initiator. Thus, a composition was
obtained from
    different methacryloyl monomers.
            THERE ARE 10 CITED REFERENCES AVAILABLE FOR THIS RECORD
RE.CNT 10
             ALL CITATIONS AVAILABLE IN THE RE FORMAT
L3 ANSWER 9 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
AN 2005:13763 CAPLUS
DN
    142:103247
    High-sensitivity shrink-proof holographic recording materials containing
    epoxides, their manufacture, and their recording
IN
    Sasa, Nobumasa
PA
    Konica Minolta Medical & Graphic, Inc., Japan
    Jpn. Kokai Tokkyo Koho, 20 pp.
SO
    CODEN: JKXXAF
DТ
    Patent
LA
    Japanese
FAN.CNT 1
    PATENT NO.
                  KIND DATE APPLICATION NO. DATE
                              20050106 JP 2003-167597
PI JP 2005003958
                       A
                                                               20030612
PRAI JP 2003-167597
                              20030612
    MARPAT 142:103247
OS
AB
    The holog, recording materials contain (A) epoxides containing ≥1
    substituted oxirane rings on \alpha and/or \beta sites of oxirane rings,
    epoxidized fatty acid esters, epoxidized fatty acid glycerides, (B)
```

compds. and photoradical polymerization initiators. The holog, recording materials form matrixes by 21 polymerization reaction selected from cationic epoxy polymerization, cationic vinyl ether polymerization, cationic

alkenyl ether polymerization, cationic arene ether polymerization, cationic ketene acetal

polymerization, epoxy-amine step polymerization, epoxy-mercaptan step polymerization, unsatd.

ester-amine step polymerization, unsatd. ester-mercaptan step polymerization, vinyl-silicone hydride step polymerization, isocyanate-hydroxyl step

polymerization, and

isocyanate-anine step polymerization In another alternative, the holog-recording materials form matrixes by curing of inorg, or organic matrix precursors which may comprise RnM(OR')4-n (M =  $\geq 3$ -valent metal element, preferably, Si, Ti, Ge, Zr, V, Al; R = alkyl, allyl; R' = CS4 lower alkyl; n = 1, 2). The holog, recording materials are are manufactured by mixing matrix-forming substances, their curing to give matrixes, and irradiation with actinic light for holog, recording.

L3 ANSWER 10 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN

KIND DATE

- AN 2004:1014409 CAPLUS
- DN 142:7357
- TI Active energy curable resin compositions with good curability and low reflectance angle for optical disks
- IN Makino, Shinji
- PA Mitsubishi Rayon Co., Ltd., Japan
- SO Jpn. Kokai Tokkyo Koho, 17 pp.
- CODEN: JKXXAF

PATENT NO.

- DT Patent
- LA Japanese

FAN.CNT 1

	JP 2004331872 JP 2003-131585	A	20041125	JP 2003	-131585	20030509	
	Title compns. compr	ise (A)		ving ≥2	oxetane		
	rings, (B) compds.						
	photoinitiators, (I						
	group, and (E) radi	cal pho	toinitiator	s. Thus,	a composition	comprising OXT	121
	25, YD 8125 bispher	ol A di	glycidyl et	her 25, U	VI 6990 photoi	nitiator 3.0,	
	U 2PHA diacrylate 5	.0, and	Irgacure 1	84 1.0 pa	rts was applie	d on a	
	silver-coated Panli						
	pressure mercury la					angle	
	0.16° initially and						
	transmittance 91% a	t. 400 n	m. 93% at 5	00 nm, an	d 93% at 700 n	m, good	

APPLICATION NO.

DATE

- L3 ANSWER 11 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 2004:996235 CAPLUS
- DN 141:429659
- TI Photocuring/thermosetting ink-jet composition and printed wiring board using same
- IN Kakinuma, Masahisa; Kusama, Masatoshi; Ushiki, Shigeru
- PA Taiyo Ink Manufacturing Co., Ltd., Japan

surface hardness and reliability.

- SO PCT Int. Appl., 21 pp. CODEN: PIXXD2
- DT Patent

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LA
   Japanese
FAN.CNT 1
    PATENT NO.
                       KIND DATE
                                      APPLICATION NO.
                                                             DATE
                              20041118 WO 2004-JP6029 20040507
    WO 2004099272
PT
                        A1
        W: AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH,
            CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD,
            GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC,
            LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NA, NI,
            NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SY,
            TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW
        RW: BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW, AM,
            AZ, BY, KG, KZ, MD, RU, TJ, TM, AT, BE, BG, CH, CY, CZ, DE, DK,
            EE, ES, FI, FR, GB, GR, HU, IE, IT, LU, MC, NL, PL, PT, RO, SE,
             SI, SK, TR, BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE,
            SN, TD, TG
    EP 1624001
                               20060208
                                          EP 2004-731714
                                                                  20040507
        R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT,
             IE, SI, FI, RO, CY, TR, BG, CZ, EE, HU, PL, SK
    CN 1784432
                         Α
                               20060607
                                          CN 2004-80012609
                                                                  20040507
    US 2006058412
                         A1
                               20060316
                                           US 2005-269836
                                                                  20051109
PRAI JP 2003-131742
                         Α
                               20030509
    WO 2004-JP6029
                         W
                               20040507
    A photocuring/thermosetting ink-jet composition contains (A) a monomer having a
AB
     (meth)acryloyl group and a thermosetting functional group in the
    mol., (B) a photoreactive diluent other than the component (A) having a
    weight-average mol. weight of not more than 700, and (C) a photopolymn.
initiator,
    and has a viscosity of not more than 150 mPa·s at 25°. A
    solder resist pattern is directly drawn on a printed wiring board by an
    ink-jet printer using the above-mentioned composition, and the pattern is
    primarily cured by irradiation with an active energy beam and then further
    cured by heat.
RE.CNT 15
             THERE ARE 15 CITED REFERENCES AVAILABLE FOR THIS RECORD
             ALL CITATIONS AVAILABLE IN THE RE FORMAT
L3
    ANSWER 12 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
AN
    2003:1000504 CAPLUS
DN
    141:242819
    Product class 4: organometallic complexes of copper
AU
    Heaney, H.; Christie, S.
CS
    Dept. of Chemistry, University of Loughborough, Loughborough, LE11 3TU, UK
SO
    Science of Synthesis (2004), 3, 305-662
    CODEN: SSCYJ9
PB
    Georg Thieme Verlag
DΤ
    Journal; General Review
    English
LA
AB
    A review. The use of copper and related complexes in applications to organic
    synthesis is reviewed.
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- L3 ANSWER 13 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 2003:929612 CAPLUS
- DN 139:397036
- TI Oxetane-base polyol (meth)acrylates, their curable compositions, and hard coatings containing them with good heat and water resistance

RE.CNT 1706 THERE ARE 1706 CITED REFERENCES AVAILABLE FOR THIS RECORD ALL CITATIONS AVAILABLE IN THE RE FORMAT

- IN Sauchi, Yasuyuki; Sasaki, Hiroshi
- PA Toa Gosei Chemical Industry Co., Ltd., Japan SO Jpn. Kokai Tokkyo Koho, 13 pp.
- CODEN: JKXXAF
- DT Patent LA Japanese
- FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI PRAI	JP 2003335854 JP 2002-143719	A	20031128 20020517	JP 2002-143719	20020517

- AB The invention relates to the (meth)acrylates having 22 (meth) acryloyl groups manufactured by heat-cationic-polymerizing I (Rl = H, alkyl, aryl, arylalkyl) to obtain polyols and esterifying them with (meth)acrylic acid. Thus, a composition comprising 3-ethyl-3-(hydroxymethyl)oxetane homopolymer acrylate was applied on a substrate and UV-cured to give a coating showing pencil hardness 4H, storage modulus 1.08 + 109 at 210°, and water absorption 1.32%.
- L3 ANSWER 14 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 2003:368907 CAPLUS
- DN 138:369365
- TI Oxetane-containing (meth)acrylate esters, their manufacture, and
- their use as dental monomers and monomers for grafting polyolefins
- IN Miyazaki, Kazuhisa; Ota, Seiji; Akie, Hideyuki
- PA Mitsui Chemicals Inc., Japan
- SO Jpn. Kokai Tokkyo Koho, 6 pp.
- CODEN: JKXXAF
- DT Patent
- LA Japanese

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI JP 2003137878 PRAI JP 2001-332394	A	20030514	JP 2001-332394	20011030
OS MARPAT 138:369365				

OS GI

$$\begin{array}{c} CH_2 \\ R^1 \\ O \\ O \\ \end{array} \qquad \begin{array}{c} CH_2 \\ O \\ CR^2 - O - CH_2 - CO) \\ n - O \\ \end{array} \qquad \begin{array}{c} R^2 \\ O \\ I \\ O \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} R^2 \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} CH_2 \\ O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ O \\ \end{array} \qquad \begin{array}{c} O \\ O \\ \\$$

AB Title esters I [R1 = H, Me; R2 = (ether bond-containing) linear or branched alkylene; R3 = linear alkyl; n = 1-4], useful for coatings and adhesives as well, are manufactured by ring-cleavage esterification of lactones II (R2 = same as above) with 3-alkyl-3-hydroxymethyloxetane in the presence of base catalysts, followed by esterification of the resulting products with (meth)acryloyl halide. Thus, 1,4-dioxan-2-one was reacted with 3-ethyl-3-hydroxymethyloxetane in the presence of K2CO3 to give 28% 3-ethyl-3-oxetanylmethyl 2-hydroxyethoxyacetate, which was esterified with acryloyl chloride to give 40% 3-ethyl-3-oxetanylmethyl 2-acryloxyethoxyacetate.

- ANSWER 15 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 2003:366797 CAPLUS
- DN 138:369360
- Oxetane-containing (meth) acrylate esters, their manufacture, and
- their use as dental monomers and monomers for grafting polyolefins
- IN Miyazaki, Kazuhisa; Ota, Seiji
- PA Mitsui Chemicals Inc., Japan
- so Jpn. Kokai Tokkyo Koho, 6 pp.
- CODEN: JKXXAF
- DT Patent
- LA Japanese FAN.CNT 1

GΙ

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PI	J	P		2	0	0	3	1	3	7	8	7	7		

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PRAI	JP 2003137877 JP 2001-330883 MARPAT 138:369360	A	20030514 20011029	JP 2001-330883	20011029

$$\begin{array}{c} R^1 \\ H_2 C = \begin{matrix} c \\ - \end{matrix} \\ - \begin{matrix} co \\ - \end{matrix} \\ - \end{matrix} \\ - \begin{matrix} co \\ - \end{matrix} \\ - \end{matrix} \\ - \begin{matrix} co \\ - \end{matrix} \\ - \end{matrix} \\ - \begin{matrix} co \\ - \end{matrix} \\ - \end{matrix} \\ - \begin{matrix} co \\ - \end{matrix} \\ - \end{matrix} \\ - \begin{matrix} co \\ - \end{matrix} \\ - \end{matrix} \\ - \begin{matrix} co \\ - \end{matrix} \\ - \end{matrix} \\ - \begin{matrix} co \\ - \end{matrix} \\ - \end{matrix} \\ - \end{matrix} \\ - \begin{matrix} co \\ - \end{matrix} \\ - \end{matrix} \\ - \end{matrix} \\ - \begin{matrix} co \\ - \end{matrix} \\ - \end{matrix} \\ - \end{matrix} \\ - \begin{matrix} co \\ - \end{matrix} \\ - \end{matrix} \\ - \end{matrix} \\ - \end{matrix} \\ - \begin{matrix} co \\ - \end{matrix} \\ -$$

Title esters I [R1 = H, Me; R2 = (ether bond-containing) linear or branched alkylene; R3 = linear alkyl; n = 1-4], useful for coatings and adhesives as well, are manufactured by transesterification between HO(R2CO2)nR4 (R2, R4, n = same as above) and 3-alkyl-3-hydroxymethyloxetane in the presence of catalysts, followed by esterification of the resulting products with

- (meth)acryloyl halide. Thus, Et lactate was reacted with 3-ethyl-3-hydroxymethyloxetane in the presence of Ti(OCHMe2)4 to give 80% 3-ethyl-3-oxetanylmethyl lactate, which was esterified with acryloyl chloride to give 89% 3-ethyl-3-oxetanylmethyl 2-acryloxypropanoate.
- L3 ANSWER 16 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 2003:352823 CAPLUS
- DN 139:85711
- TI Combining Covalent and Noncovalent Cross-Linking: A Novel Terpolymer for Two-Step Curing Applications
- El-Ghayoury, Abdelkrim; Hofmeier, Harald; de Ruiter, Barteld; Schubert, AII Ulrich S.
- CS Laboratory of Macromolecular Chemistry and Nanoscience, Eindhoven University of Technology and Dutch Polymer Institute, Eindhoven, 5600, Neth.
- SO Macromolecules (2003), 36(11), 3955-3959 CODEN: MAMOBX; ISSN: 0024-9297
- PB American Chemical Society
- DT Journal
- LA English
- A terpolymer of poly(Bu acrylate) bearing terpyridine as well as AB oxetane units was synthesized by free radical polymerization and characterized using NMR, UV-vis, and GPC. Subsequently, UV-vis expts. indicated clearly a noncovalent crosslinking of the terpyridine moleties by addition of iron(II) ions. Moreover, the ability of covalent crosslinking was studied by polymerizing the oxetane rings utilizing Lewis acids. IR spectroscopy and DSC expts. clearly revealed the success of the combination of both steps when utilizing iron(II) ions and AlCl3. RE.CNT 53 THERE ARE 53 CITED REFERENCES AVAILABLE FOR THIS RECORD ALL CITATIONS AVAILABLE IN THE RE FORMAT
- L3 ANSWER 17 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 2002:625102 CAPLUS
- DN 137:248043
- Atom transfer radical copolymerization (ATRCP) of a monomer bearing an oxetane group
- AU Singha, Nikhil K.; de Ruiter, Barteld; Schubert, Ulrich S.
- CS Lab. Macromolecular Organic Chem., Center Nanomaterials, Eindhoven Univ. Technology, Eindhoven, 5600 MB, Neth.
- so Polymer Preprints (American Chemical Society, Division of Polymer Chemistry) (2002), 43(2), 165-166 CODEN: ACPPAY; ISSN: 0032-3934
- PB American Chemical Society, Division of Polymer Chemistry
- ידת Journal; (computer optical disk)
- LA English
- AB The atom transfer radical polymerization of Me methacrylate with 3-ethyl-3-(acryloyloxymethyl)oxetane is described. Anal. of the copolymer confirmed that the oxetane ring did not open during polymerization
- RE.CNT 14 THERE ARE 14 CITED REFERENCES AVAILABLE FOR THIS RECORD ALL CITATIONS AVAILABLE IN THE RE FORMAT
  - ANSWER 18 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN L3
- AN 2001:663120 CAPLUS
- DN 136:6399
- Synthesis and photochemical reaction of high performance UV curing

- oligomers
- AU Nishikubo, Tadatomi; Kamevama, Atsushi
- CS Department of Applied Chemistry, Faculty of Engineering, Kanagawa University, Kanagawa-ku, Yokohama, 221-8686, Japan
- SO Polymer Preprints (American Chemical Society, Division of Polymer Chemistry) (2001), 42(2), 722-723 CODEN: ACPPAY: ISSN: 0032-3934
- PB American Chemical Society, Division of Polymer Chemistry
- DT Journal; (computer optical disk)
- LA English
- AB Calixarene derivs. containing (meth)acrylate, vinyl ether, propargyl ether, oxetane, oxirane, or spiro ortho ester groups were synthesized by reaction of calixarenes with (meth)acrylic acid derivs., vinyl ether compds., propargyl bromide, oxetane derivs., epibromohydrin, and spiro ortho ester derivs. The calixarene derivs. containing photoreactive groups had excellent thermal stability and high photochem. reactivity. The calixarene derivs. are of interest for UV curing systems, e.g., inks, coatings, solder masks, adhesives, and microelectronics uses.
- RE.CNT 11 THERE ARE 11 CITED REFERENCES AVAILABLE FOR THIS RECORD ALL CITATIONS AVAILABLE IN THE RE FORMAT
- L3 ANSWER 19 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 2001:143711 CAPLUS
- DN 134:194666
- TI Actinic ray-curable sulfur-containing compositions with good curability and manufacture of coatings
- IN Maruyama, Tsutomu
- PA Kansai Paint Co., Ltd., Japan
- SO Jpn. Kokai Tokkyo Koho, 7 pp.
- CODEN: JKXXAF
- DT Patent
- LA Japanese
- FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI	JP 2001055507	A	20010227	JP 1999-232626	19990819
PRAI	JP 1999-232626		19990819		

- AB The compns. contain (A) 5-100 parts S-containing compds. manufactured by a reaction
  - of compds. (average mol. weight 150-1000) having ≥2 SH and compds. having l acryloyl group and ≥2 alkoxysilyl groups and optional compds. having l acryloyl group and ≥1 epoxy groups and/or oxetane rings at acryloyl/SH molar ratio
    - 0.5-1.2, (B) 0-95 parts photochem. cationically reactive compds., and (C) 0.05-20 parts photochem. cationic polymerization initiators. Thus, a
- composition

containing 100 parts reaction product of pentaerythritol tetrakis(mercaptoacetate) and 3-acryloxypropyl trimethoxysilane and 4 parts CI 2758 (sulfonium salt-based initiator) was applied on a glass plate and cured by UV-irradiation to give a coating showing pencil hardness 6H.

- L3 ANSWER 20 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 1999:810952 CAPLUS
- DN 132:51248
- TI Photocurable hydrolyzed silane composition and photocured product
- IN Sekiguchi, Manabu; Sugiyama, Naoki; Sato, Hozumi

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PA Jsr Corp., Japan
SO
   Eur. Pat. Appl., 38 pp.
     CODEN: EPXXDW
     Patent
T.A
    English
FAN.CNT 1
                        KIND DATE APPLICATION NO.
                                               -----
   EP 965618
                         A1 19991222 EP 1999-111732 19990617
B1 20040102
     EP 965618
         R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT,
              IE, SI, LT, LV, FI, RO
     JP 2000001648 A 20000107
                                              JP 1998-170885
                                                                       19980618
     JP 2000026730
                          A
                                 20000125 JP 1998-194817
                                                                       19980709
                         B 20020411 TW 1999-88110061
A 20000125 KR 1999-22643
     TW 482817
                                                                       19990616
TW 46281/ B 20020411 TW 1999-88110001

KR 2000006232 A 20000125 KR 1999-22643

US 6207728 B1 20010327 US 1999-335269

JP 2000109560 A 20000418 JP 1999-219938

JP 2000109695 A 20000418 JP 1999-220750

PRAI JP 1999-170885 A 19980709

JP 1999-19417 A 19980709
                                                                       19990617
                                                                       19990617
                                                                      19990804
     JP 1998-220512 A 19980804
JP 1998-220513 A 19980804
JP 1998-220514 A 19980804
     Disclosed is a photo-curable composition comprising the following components
AB
     (A) to (C): (A) hydrolyzable silane compound represented by the general
     formula (1) or a hydrolyzate thereof: (R1)pSi(X)4-p (1) wherein R1 is a
     non-hydrolyzable organic group having 1 to 12 carbon atoms, X is a
     hydrolyzable group, and p is an integer of 0 to 3; (B) photo acid
     generator; and (C) dehydrating agent. By such constitution, it is
     possible to provide a photo-curable composition which has a rapid photo-curable
     rate, is excellent in characteristics such as storage stability, heat
     resistance, weather-ability, scratch resistance and the like, and is
     applicable to base materials having low heat resistance such as plastics,
     as well as a cured product obtained therefrom.
               THERE ARE 3 CITED REFERENCES AVAILABLE FOR THIS RECORD
               ALL CITATIONS AVAILABLE IN THE RE FORMAT
L3 ANSWER 21 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
AN
    1998:653719 CAPLUS
DN 129:276496
     Hydrolyzable and polymerizable oxetanesilanes
TN
     Moszner, Norbert; Volkel, Thomas; Stein, Sabine; Rheinberger, Volker
PΑ
     IVOCLAR A.-G., Liechtenstein
so
    Eur. Pat. Appl., 21 pp.
     CODEN: EPXXDW
DT
     Patent
LA
     German
FAN.CNT 1
                                 DATE APPLICATION NO. DATE
                         KIND
                         A2 19980930
ΡI
     EP 867443
                                            EP 1998-250089
                                                                       19980313
                  A3 20000628
B1 20030806
     EP 867443
     EP 867443
         R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT,
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IE, SI, LT, LV, FI, RO

	DE 19	714324	A1	19981029	DE	1997-19714324	19970325
	DE 19	714324	B4	20040902			
	AT 24	6691	T	20030815	AT	1998-250089	19980313
	CA 22	32960	A1	19980925	CA	1998-2232960	19980324
	CA 22	32960	C	20020129			
	JP 10	1330485	A	19981215	JP	1998-77593	19980325
	US 60	34151	A	20000307	US	1998-47592	19980325
	US 60	96903	A	20000801	US	1998-47659	19980325
	US 62	84898	B1	20010904	US	2000-591358	20000609
PRAI	DE 19	97-19714324	A	19970325			
	US 19	97-52563P	P	19970715			
	US 19	97-52605P	P	19970715			
	US 19	98-47659	A3	19980325			
0.0	MADDA	m 120.276406					

OS MARPAT 129:276496

AB The title compds., with specified structure, which can be polymerized at room temperature with very little shrinkage, are prepared Stirring 3-ethyl-3-(hydroxymethyl)oxetane with acryloyl

chloride in Et20 containing collidine at room temperature for 6 h gave 50% acrylate

ester, reaction of which with 3-(trimethoxysilvl)-1-propanethiol at room temperature for 48 h gave 81% (3-ethyl-3-oxetanyl)methyl 3-[[3-(trimethoxysilyl)propyl]thio]propionate (I). Hydrolytic polymerization of an equimolar mixture of I and Me2Si(OMe)2 in refluxing EtOH gave a condensate which was used in a dental cement.

- L3 ANSWER 22 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 1997:579788 CAPLUS
- DN 127:235757
- TI Coating composition comprising a bicyclo- or spiro-orthoester-functional compound
- Van Den Berg, Keimpe Jan; Hobel, Klaus; Klinkenberg, Huig; Noomen, Arie; Van Oorschot, Josephus Christiaan
- Akzo Nobel N.V., Neth. PA
- SO PCT Int. Appl., 69 pp.
- CODEN: PIXXD2

DT		tent																
		glish																
FAN.																		
	PA:	PENT :	NO.			KIN:	D	DATE			APPI	ICAT	ION :	NO.		D.	ATE	
PT	WO.	9731	073			A1	-	1997	0828		WO 1	997-	EP89	 2		1	9970	221
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		vı .										JP,						
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												TR.						F 1,
		DM.										DE,						CD
		IVW :																
								PI,	SE,	Dr,	DU,	CF,	CG,	CI,	CM,	GA,	GN,	Pil.,
						TD,												
		1002				C2		1997				996-						
	CA	2247	126			A1		1997	0828		CA 1	997-	2247	126		1	9970:	221
	AU	9720	930			A		1997	0910		AU 1	997-	2093	0		1	9970:	221
	ZA	9701	542			A		1998	0727		ZA 1	997-	1542			1	9970:	221
	EP	8821	06			A1		1998	1209		EP 1	997-	9061	23		1	9970:	221
	EP	8821				В1		2000										
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	CN	1214				A		1999	0421		CN 1	997-	1932	66		1	9970:	221

В	ЗR	1128851 9707735 942051 R: AT, BE	e en	B A A2	19990915		19970221	1
		IE, FI		DE,	DR, ES, ER,	GD, GR, 11, L1, L0,	NL, SE, PC, F	٠,
J	JΡ	2000506908		T	20000606	JP 1997-529818	1997022	1
A	ΥAT	195331		T	20000815	AT 1997-906123	19970221	1
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		9803859		A	19981020	NO 1998-3859	19980823	
		754919		B2	20021128	AU 2000-56513	20000908	
		3034728		Т3	20010131	GR 2000-402417	20001030	
		2002161135		A1	20021031	US 2001-935308	20010822	2
		6593479		B2	20030715			
		1996-100242		A	19960223			
		1996-15878I		P	19960422			
		1997-906123		A3	19970221			
		1997-804485	5	A3	19970221			
M	10	1997-EP892		W	19970221			

AB A coating composition comprises a first compound of ≥1 bicyclo- or spiro-orthoester group and a second compound of ≥2 hydroxyl-reactive groups. The latent hydroxyl groups of the bicyclo- or spiro-orthoester groups have to be deblocked and reacted with the hydroxyl-reactive groups of the second compound to be cured. Bicyclo-orthoester compds. are made from the corresponding oxetane compound, as are polymers comprising ≥1 bicyclo- or spiro-orthoester group. Thus, Desmodur N 3390 was mixed with 1,4-diethyl-2,6,7-trioxabicyclo[2.2.2]octane in the presence of p-MeC6H4SO3H and Bu2Sn dilaurate in solvent and sprayed onto steel panels showing pot life >1 day and dry time 100 min.

- L3 ANSWER 23 OF 28 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 1996:709842 CAPLUS
- DN 125:331792
- TI Activation energy-curable coating compositions containing oxetane compounds with improved curability, gloss, adhesion, hardness, and crack resistance
- IN Niwa, Makoto; Oota, Hiroyuki
- PA Toa Gosei Kk, Japan
- SO Jpn. Kokai Tokkyo Koho, 11 pp.
- CODEN: JKXXAF
- DT Patent
- LA Japanese
- DAN CMT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
	JP 08239623 JP 1995-64801	A	19960917 19950228	JP 1995-64801	19950228
GI					

6



AB The coating compns. comprise compds. having 1-4 oxetane rings, cationic photopolymn. initiators, and optionally epoxides, vinyl ethers, and (meth)acryloyl compds. Thus, 100 parts compds. having 2 oxetane rings I and 4 parts diphenyl[p-(phenylthio)phenyl]sulfonium hexafluoroantimonate were stirred to give a composition, which was applied to a plywood and exposed to UV to give test pieces with JIS A hardness 7, cross-cut adhesion 8-10, >90% in 60° gloss, pencil hardness 3H, and .apprx.0 crack after thermal crack test (80° for 2 h, -20° for 2 h, repeated 2 times).

### => d 118:7419 bib abs hitstr

ANSWER 1 CAPLUS COPYRIGHT 2007 ACS on STN

- 1993:7419 CAPLUS
- 118:7419
- Structure and reactivity relationships in the photoinitiated cationic polymerization of oxetane monomers
- ΔII Crivello, J. V.; Sasaki, H.
- CS Dep. Chem., Rensselaer Polytech. Inst., Troy, NY, 12180-3590, USA
- so Journal of Macromolecular Science, Pure and Applied Chemistry (1993), A30(2-3), 189-206
  - CODEN: JSPCE6; ISSN: 1060-1325 Journal
- DT LA English
- AB A series of oxetane-containing monomers possessing several different types of functional groups was prepared and characterized. These monomers were compared among themselves, and conclusions were drawn with respect to the influence of structure on their reactivities in photoinitiated cationic polymerization

=> FIL STNGUIDE		
COST IN U.S. DOLLARS	SINCE FILE	TOTAL
	ENTRY	SESSION
FULL ESTIMATED COST	73.56	276.69
DISCOUNT AMOUNTS (FOR QUALIFYING ACCOUNTS)	SINCE FILE	TOTAL
	ENTRY	SESSION
CA SUBSCRIBER PRICE	-18.72	-67.86

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FILE CONTAINS CURRENT INFORMATION.

LAST RELOADED: Apr 20, 2007 (20070420/UP).

=> d 118:7419 bib abs cn

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'BIB' IS NOT A VALID ACCESSION NUMBER 'ABS' IS NOT A VALID ACCESSION NUMBER

'CN' IS NOT A VALID ACCESSION NUMBER

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=> d 118:7419 bib abs str

'118:7419' IS NOT A VALID ACCESSION NUMBER

'BIB' IS NOT A VALID ACCESSION NUMBER

'ABS' IS NOT A VALID ACCESSION NUMBER

'STR' IS NOT A VALID ACCESSION NUMBER

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### => help accession

There is one format that may be used to input a STNGUIDE Accession Number in the DISPLAY ACC or PRINT ACC command.

The format is shown here:

STN output format ----- 210

=> fil req

 COST IN U.S. DOLLARS
 SINCE FILE ENTRY
 TOTAL ENTRY

 FULL ESTIMATED COST
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 276.99

 DISCOUNT AMOUNTS (FOR QUALIFYING ACCOUNTS)
 SINCE FILE ENTRY SESSION ENTRY
 TOTAL ENTRY SESSION 0.00

 CA SUBSCRIBER PRICE
 0.00
 -67.86

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STRUCTURE FILE UPDATES: 26 APR 2007 HIGHEST RN 933069-51-3 DICTIONARY FILE UPDATES: 26 APR 2007 HIGHEST RN 933069-51-3

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TSCA INFORMATION NOW CURRENT THROUGH December 2, 2006

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http://www.cas.org/support/stngen/stndoc/properties.html

=>

Uploading C:\Program Files\Stnexp\Queries\rkc072.str

```
chain nodes:
5 6 7 8 9 10 11 12 13 14
ring nodes:
1 2 3 4
chain bonds:
2-5 2-13 6-13 6-7 6-14 8-10 8-9 8-14 10-11 10-12
ring bonds:
1-2 1-4 2-3 3-4
exact/norm bonds:
```

2-5 2-13 6-13 6-7 6-14 8-9 8-14 10-12 exact bonds: 1-2 1-4 2-3 3-4 8-10 10-11 isolated ring systems: containing 1:

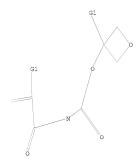
G1:Et,n-Pr,n-Bu,t-Bu

Match level :

1:Atom 2:Atom 3:Atom 4:Atom 5:CLASS 6:CLASS 7:CLASS 8:CLASS 9:CLASS 10:CLASS 11:CLASS 12:CLASS 13:CLASS 14:CLASS

## L6 STRUCTURE UPLOADED

=> d 16 L6 HAS NO ANSWERS L6 STR



G1 Et,n-Pr,n-Bu,t-Bu

Structure attributes must be viewed using STN Express query preparation.

=> s 16 ful FULL SEARCH INITIATED 11:15:34 FILE 'REGISTRY' FULL SCREEN SEARCH COMPLETED - 0 TO ITERATE

100.0% PROCESSED 0 ITERATIONS SEARCH TIME: 00.00.01

0 ANSWERS

## L7 0 SEA SSS FUL L6

=>

Uploading C:\Program Files\Stnexp\Queries\rkc072b.str

```
chain nodes:
5 6 7 8 9 10 11 12 13 14 18
ring nodes:
1 2 3 4
chain bonds:
2-5 2-18 6-13 6-7 6-14 8-10 8-9 8-14 10-11 10-12 13-18
ring bonds:
1-2 1-4 2-3 3-4
exact/norm bonds:
2-5 6-13 6-7 6-14 8-9 8-14 10-12 13-18
exact bonds:
1-2 1-4 2-3 2-18 3-4 8-10 10-11
isolated ring systems:
containing 1:
```

G1:Et,n-Pr,n-Bu,t-Bu

Match level :

1:Atom 2:Atom 3:Atom 4:Atom 5:CLASS 6:CLASS 7:CLASS 8:CLASS 9:CLASS 10:CLASS 11:CLASS 12:CLASS 13:CLASS 14:CLASS 18:CLASS

L8 STRUCTURE UPLOADED

=> d 18 L8 HAS NO ANSWERS L8 STR

G1 O

G1 Et,n-Pr,n-Bu,t-Bu

Structure attributes must be viewed using STN Express query preparation.

=> s 18 ful

FULL SEARCH INITIATED 11:17:25 FILE 'REGISTRY'
FULL SCREEN SEARCH COMPLETED - 2 TO ITERATE

100.0% PROCESSED 2 ITERATIONS

0 ANSWERS

SEARCH TIME: 00.00.01

L9 0 SEA SSS FUL L8

=>

Uploading C:\Program Files\Stnexp\Queries\rkc072c.str

```
chain nodes:
5 6 7 8 9 10 11 12 13 14 18 21 22
ring nodes:
1 2 3 4
chain bonds:
2-5 2-18 6-13 6-7 6-14 8-10 8-9 8-21 10-11 10-12 13-18 14-22 21-22
ring bonds:
1-2 1-4 2-3 3-4
exact/norm bonds:
2-5 6-13 6-7 6-14 8-9 8-21 10-12 13-18 14-22 21-22
exact/norm bonds:
1-2 1-4 2-3 2-18 3-4 8-10 10-11
isolated ring systems:
containing 1:

G1:Et,n-Pr,n-Bu,t-Bu
Match level:
```

Page 77

1:Atom 2:Atom 3:Atom 4:Atom 5:CLASS 6:CLASS 7:CLASS 8:CLASS 9:CLASS 10:CLASS 11:CLASS 12:CLASS 13:CLASS 14:CLASS 18:CLASS 21:CLASS 22:CLASS Generic attributes :

22:

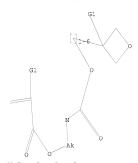
Type of chain : Linear Number of Carbon Atoms : less than 7

STR

L10 STRUCTURE UPLOADED

=> d L10 HAS NO ANSWERS

L10



G1 Et,n-Pr,n-Bu,t-Bu

Structure attributes must be viewed using STN Express query preparation.

=> s 110 ful

FULL SEARCH INITIATED 11:19:32 FILE 'REGISTRY' FULL SCREEN SEARCH COMPLETED -16 TO ITERATE

100.0% PROCESSED 16 ITERATIONS SEARCH TIME: 00.00.01

0 ANSWERS

L11 0 SEA SSS FUL L10

Uploading C:\Program Files\Stnexp\Queries\rkc072d.str

chain nodes:
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ring nodes:
1 2 3 4
chain bonds:
2-5 2-21 6-13 6-7 6-14 8-10 8-9 8-18 10-11 10-12 13-21 14-19 18-20
19-20
ring bonds:
1-2 1-4 2-3 3-4
exact/norm bonds:
6-13 6-7 6-14 8-9 8-18 13-21 14-19 18-20
exact bonds:
1-2 1-4 2-3 2-5 2-21 3-4 8-10 10-11 10-12 19-20
isolated ring systems:
containing 1:

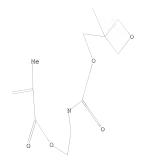
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Match level: 1:Atom 2:Atom 3:Atom 4:Atom 5:CLASS 6:CLASS 7:CLASS 8:CLASS 9:CLASS 10:CLASS 11:CLASS 12:CLASS 13:CLASS 14:CLASS 18:CLASS 19:CLASS 20:CLASS 21:CLASS

# L12 STRUCTURE UPLOADED

=> d L12 HAS NO ANSWERS L12 STR

1 ANSWERS



G1 Et,n-Pr,n-Bu,t-Bu

Structure attributes must be viewed using STN Express query preparation.

=> s k12 ful L13 19180 K12

SEARCH TIME: 00.00.01

=> s 112 ful FULL SEARCH INITIATED 11:22:26 FILE 'REGISTRY' FULL SCREEN SEARCH COMPLETED -6 TO ITERATE

100.0% PROCESSED 6 ITERATIONS

L14 1 SEA SSS FUL L12

=> d

- L14 ANSWER 1 OF 1 REGISTRY COPYRIGHT 2007 ACS on STN
- RN 862453-34-7 REGISTRY
- ED Entered STN: 02 Sep 2005
- CN 2-Propenoic acid, 2-methyl-, 2-[[[(3-ethyl-3-oxetanyl)methoxy]carbonyl]ami no]ethyl ester (9CI) (CA INDEX NAME) C13 H21 N O5
- MF
- SR
- LC STN Files: CA, CAPLUS, USPATFULL

\*\*PROPERTY DATA AVAILABLE IN THE 'PROP' FORMAT\*\*

1 REFERENCES IN FILE CA (1907 TO DATE)
1 REFERENCES IN FILE CAPLUS (1907 TO DATE)

=> fil caplus COST IN U.S. DOLLARS SINCE FILE TOTAL ENTRY SESSION FULL ESTIMATED COST 703.85 980.84 DISCOUNT AMOUNTS (FOR OUALIFYING ACCOUNTS) SINCE FILE TOTAL ENTRY SESSION -67.86 CA SUBSCRIBER PRICE 0.00

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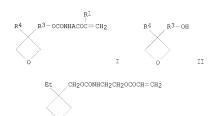
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L15 1 L14

=> d bib abs hitstr

- L15 ANSWER 1 OF 1 CAPLUS COPYRIGHT 2007 ACS on STN
- AN 2005:823679 CAPLUS
- DN 143:212295
- TI Preparation of polymerizable (meth)acryloyl group-containing oxetane monomers

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TN
     Kamata, Hirotoshi; Morinaka, Katsutoshi; Uchida, Hiroshi
     Showa Denko K.K., Japan
     PCT Int. Appl., 21 pp.
SO
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     Patent
LA
     English
FAN.CNT 1
     PATENT NO.
                          KIND
                                 DATE
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                                 20050818
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             LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NA, NI, NO,
             NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SY, TJ,
              TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW
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     US 2004-545488P
                           Ρ
                                 20040219
     WO 2005-JP2381
                           W
                                 20050209
     MARPAT 143:212295
GΙ
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AB Polymerizable (meth)acryloyl group-containing oxetane [I; A = OR2, direct bond; R2 = divalent hydrocarbyl (which may contain an oxygen atom in the

main chain); R1 = H, CH3; R3 = C1-6 (un)branched alkylene; R4 = C1-6 (un)branched alkyl] monomers are prepared in high yield and selectivity by the addition reaction of (meth)acrylate isocyanates HZC:C(R1)CO(A)NCO with 3-(hydroxyalkyl)-substituted oxetanes (II) in the presence of a tertiary amine or tin-compound catalyst. Thus, 2-acryloyloxyethyl isocyanate was mixed in Et acetate containing dibutyltin dilaurate and reacted with 3-ethyl-3-(hydroxymethyl)oxetane, producing an oxetanyl group-containing methacrylate ester monomer (III).

IT 862453-34-7P

RL: IMF (Industrial manufacture); PREP (Preparation)
(preparation of polymerizable (meth)acryloyl group-containing oxetane
monomers)

RN 862453-34-7 CAPLUS

CN 2-Propenoic acid, 2-methyl-, 2-[[[(3-ethyl-3-oxetanyl)methoxy]carbonyl]ami no]ethyl ester (9CI) (CA INDEX NAME)

=> d his

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(FILE 'HOME' ENTERED AT 10:21:10 ON 27 APR 2007)
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FILE 'CAPLUS' ENTERED AT 10:21:28 ON 27 APR 2007
L1 4682 S OXETANE
L2 11113 S ACRYLOYL

L3 28 S L1 AND L2 L4 26 S L1 AND CA

L4 26 S L1 AND CARBAMATE L5 4 S L4 AND ISOCYANATE

FILE 'STNGUIDE' ENTERED AT 10:48:08 ON 27 APR 2007

FILE 'CAPLUS' ENTERED AT 10:51:10 ON 27 APR 2007

FILE 'STNGUIDE' ENTERED AT 10:51:10 ON 27 APR 2007

FILE 'CAPLUS' ENTERED AT 10:52:52 ON 27 APR 2007

FILE 'STNGUIDE' ENTERED AT 10:52:54 ON 27 APR 2007

FILE 'CAPLUS' ENTERED AT 10:59:08 ON 27 APR 2007

FILE 'STNGUIDE' ENTERED AT 11:06:11 ON 27 APR 2007

FILE 'REGISTRY' ENTERED AT 11:09:10 ON 27 APR 2007

L6 STRUCTURE UPLOADED L7 0 S L6 FUL

L8 STRUCTURE UPLOADED
L9 C S L8 FUL

L10 STRUCTURE UPLOADED

L11 0 S L10 FUL

STRUCTURE UPLOADED

L12 STRUCTURE L13 19180 S K12 FUL 1 C L12 FUL L14 1 S L12 FUL

FILE 'CAPLUS' ENTERED AT 11:22:45 ON 27 APR 2007

L15 1 S L14

=>

Executing the logoff script...

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SESSION ENTRY -0.78 -68.64 CA SUBSCRIBER PRICE

SESSION WILL BE HELD FOR 120 MINUTES STN INTERNATIONAL SESSION SUSPENDED AT 11:31:59 ON 27 APR 2007